

**Relaxation of excited spin, orbital, and valley qubit states in ideal silicon quantum dots**

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We review and expand on previous work that treats relaxation physics of low-lying excited states in ideal, single-electron, silicon quantum dots in the context of quantum computing. These states are of three types: orbital, valley, and spin. The relaxation times depend sensitively on system parameters such as the dot size and the external magnetic field. Generally, however, orbital relaxation times are short in strained silicon ( $10^{-7}$  to  $10^{-12}$  s), spin-relaxation times are long ( $10^{-6}$  to  $\gg 1$  s), while valley relaxation times are expected to lie in between. The focus is on relaxation due to emission or absorption of phonons, but for spin relaxation we also consider competing mechanisms such as charge noise. Where appropriate, comparison is made to reference systems such as quantum dots in III-V materials and silicon donor states. The phonon-bottleneck effect is shown to be rather small in the regime of interest. We compare the theoretical predictions to some recent spin relaxation experiments and comment on the possible effects of nonideal dots.

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**I. INTRODUCTION**

The spin of an electron in silicon may act as an information carrier in future information technologies, from quantum computers to spintronics. For quantum information applications, the spin of cold, localized electrons in silicon can make a qubit with a low memory error rate due to isotope enrichment of the spin environment (a spin-0 nuclear isotope is available) and silicon's inherently weak spin-orbit interaction, which isolates information stored in the electron spin from charge movement and other noise. Quantum dots, in addition, allow for ready tunability and alignment of the confined electron (for physical transport, computation via qubit-qubit coupling, readout, initialization),<sup>1</sup> the potential for a fabrication route with present-day lithographic techniques, and the enabling of a fast, dc-controlled two-qubit gate based on Heisenberg exchange.<sup>2</sup> The goal of designing and constructing quantum computers based on quantum dots requires characterization of all their physically relevant properties. For this, it is necessary to have a toolbox full of experimental diagnostics, in this case, one-electron excited-state lifetime measurements as a function of external parameters such as temperature and magnetic field, and to be able to interpret these measurements in the light of theory.

In this paper we present calculations of the dominant spin-relaxation processes in ideal silicon quantum dot spin qubits<sup>3</sup> along with calculations for orbital and valley relaxation. Our particular emphasis is decay due to phonon coupling, since this mechanism is believed to be responsible for  $T_1$  across wide parameter regimes relevant to quantum information applications. We indicate in detail how it can be distinguished experimentally from other mechanisms.

This content is arranged as follows. We begin with a very brief review of our current status of knowledge on this topic and what this paper covers. Then, an introduction to the single-electron states in silicon quantum dots typical of heterostructures used for qubits today is given. We follow with a discussion of the electron-phonon interaction, the dominant

relaxation mechanism in these devices. We then use that theory to calculate the orbital relaxation (no spin flip) of low-lying excited states to states having the same valley index. We do this first using the electric-dipole (ED) approximation and then including all multipoles. This gives useful numbers for excited orbital state lifetimes as well as a quantitative idea of the extent of validity of the ED approximation in further calculations. Then the main subject of this paper is tackled, namely the spin-flip mechanisms relevant to quantum dots. In this section, we review and adapt the previously known "bulk" spin-flip mechanisms to the quantum dot case. We then consider new mechanisms due to structural inversion asymmetry which give the dominant spin-relaxation mechanisms for most of the magnetic field range. This is followed by comparisons with spin-relaxation mechanisms (noise, nuclei) and valley relaxation, which completes the narrative of excited lifetimes in single-electron quantum dots relevant to quantum computing. Where possible we compare the results for quantum dots with those for P donors in silicon and GaAs quantum dots, both of which are relevant reference systems.

The final section summarizes the relation of theory to experiment. It is difficult to make sharp predictions for the absolute magnitude of  $T_1$  because of strong dependencies on quantities that are usually somewhat uncertain, particularly the dot size, as well as a reliance on bulk material constants which may vary in nanostructures. We show how to overcome this problem by combining measurements of qubit spin lifetimes with measurements of excited orbital state energies and lifetimes. It is precisely for this reason that we deal in such detail with the excited states.

**II. BRIEF REVIEW AND SCOPE OF THIS WORK**

A full, experimentally verified theory of the energy relaxation processes of the excited electronic states in silicon quantum dots is important for several reasons. First, it accomplishes a major step on the experimental path to determining the quantum coherence times of isolated spins in silicon

(a preeminent goal in the verification of a qubit). Second, it helps corroborate our understanding of the material system and better characterizes the device under scrutiny; an example would be transport spectroscopy of nearby energy levels and their linewidths. Third, it provides necessary parameters needed for the design of future experiments, systems, and architectures. Indeed, if the dominant spin-qubit relaxation mechanisms are as we predict, we cannot only validate the  $T_1$  lifetimes of silicon qubits, but also retrieve the relative magnitudes of the dominant spin-orbit coupling contributions inherent in the device (important for both silicon quantum computing and silicon spintronics applications), as well as the nature and energies of the various states above the two spin-qubit states. Finally, the lifetimes of excited orbital states are relevant to optical pumping schemes, many-phonon decoherence calculations, transport spectroscopy, beyond single-spin-qubit implementations,<sup>4,5</sup> and other areas of quantum control.

It has long been known that localized spins in silicon can have exceedingly long lifetimes, even at relatively high temperatures ( $>2$  K) (Ref. 6). Theoretical predictions of spin decoherence times are notoriously difficult as many mechanisms can relax a spin, even in the more robust case of direct energy relaxation, or  $T_1$  processes, where a quantum of energy is lost to the environment. In silicon, for example, energy relaxation processes may depend on the many-valley nature of the conduction band electrons; neglecting this effect leads to incorrect predictions (to many orders of magnitude).<sup>7,8</sup> The key realization came in 1960 from Roth<sup>9,10</sup> and, independently, Hasegawa:<sup>11</sup> Spin mixing to the ( $1s$ -like) valley manifold states explains the “fast” relaxation observed for donor electrons. Soon after, Feher and Gere,<sup>6</sup> Wilson and Feher,<sup>12</sup> and Castner<sup>13,14</sup> thoroughly fleshed out the experiments and theories of donor state lifetimes in silicon. Castner was the first to calculate relaxation across different valley donor states. This body of work was the basis of some of the first proposals for electron spin qubits in silicon as a basis for a quantum computer.<sup>15</sup> This reinvigoration of the field has led to the extension of these original relaxation theories to new nanostructures like donors and quantum dots in strained silicon<sup>3,16,17</sup> and in III-V quantum dots.<sup>18,19</sup>

The region of qubit interest in our case refers to a spin qubit with finite magnetic field, well below any degeneracy with higher orbital or valley states. We can summarize the key results of this paper and prior work on qubit relaxation relevant to qubit and quantum computer design in silicon quantum dots as follows.

(1) We are concerned with the lifetimes of excited states of a 0-dimensional (0D) localized electron in silicon. The relaxation of 1D and 2D mobile electron spins has been investigated for spintronics applications. This has led to some misconceptions about electron spin relaxation in 1D and 2D vs 0D. They are, in fact, very different. For mobile electrons, scattering plays the key role,<sup>20,21</sup> and spin rotation between or during scattering events is the driver of loss of spin memory (D’yakonov-Perel and Elliott-Yafet effects<sup>22</sup>). This normally leads to spin lifetimes on the order of microseconds in silicon.<sup>21,23</sup> Since scattering is not an issue in 0D, this is an unjustified worry for spin qubits for silicon quantum computers. However, spin lifetime measurements in silicon quantum wells can help determine relevant spin-orbit coupling parameters needed for quantum spin-relaxation calculations.

(2) Spontaneous emission of a phonon is the dominant mechanism determining the spin-flip time,  $T_1$  ( $T_1$  being the characteristic time for true energy relaxation to the environment via a phonon or photon), at temperatures around 100 mK. Phonon emission is negligible because of the much lower density of final photon states. Phonon emission accompanied by a spin flip occurs due to spin-orbit mixing within the crystal. Of the “bulk” Roth<sup>9</sup> and Hasagawa<sup>11</sup> mechanisms that are relevant for donors in unstrained silicon, the “valley-repopulation” mechanism disappears with increasing [001] strain as is common in silicon quantum wells.<sup>16</sup> The “one-valley” mechanism goes to zero if the magnetic field is parallel to one of the three crystallographic axes and goes as  $B$  (Ref. 5) for other directions.<sup>17</sup>

(3) The effect of germanium in a SiGe quantum dot (QD) heterostructure is not significantly detrimental to relaxation times for growth-typical Ge concentrations<sup>16</sup> (in the virtual crystal approximation).

(4) The spin-orbit coupling (SOC) in lateral Si quantum dots comes predominantly from structural inversion asymmetry (SIA) and symmetry breaking due to interface effects leading to both Rashba-like and Dresselhaus-like SOC terms.<sup>22,24-26</sup> (The relative magnitude of Dresselhaus-like and Rashba-like SOC in silicon quantum wells or dots has yet to be verified experimentally, let alone systematically across samples.) Each term gives a characteristic magnetic field anisotropy in  $T_1$ . In ideal Si dots,  $1/T_1$  is proportional to the seventh power of the magnetic field  $B$  (Ref. 3). This contrasts sharply with GaAs quantum dots and Si donor states. For these two cases  $1/T_1 \propto B^5$  (though for different reasons). The ratio of the Rashba-like and Dresselhaus-like terms are expected to be sample dependent since in silicon they are due solely to interface effects [silicon, unlike III-Vs, has no bulk-inversion asymmetry (BIA)].

(5) Direct coherent rotations due to nearby spins in the semiconductor are possible.

(a) At zero and low magnetic fields, direct dipole-dipole magnetic coupling with the central electron qubit and other electrons in the environment can occur. These rotations are technically coherent processes, but they result in spin flips that change the longitudinal component of the qubit magnetization and thus appear like  $T_1$  processes. These processes do not depend on  $B$  and can set upper limits on observed  $T_1$  times. The strength of this interaction is reduced as the inhomogeneity of the electron line widths increases, though even one-electron spin exactly at resonance 200 nm away can cause 200 ms effective  $T_1$  lifetimes.<sup>27</sup> A full theory is beyond the scope of this paper.

(b) Coupling of spin qubits to nuclei causes  $T_2$  processes, but the mismatch of electron and nuclear energy scales due to the very different  $g$  factors of electrons and nuclei means that the hyperfine interaction is not important for  $T_1$ , which is the subject of this paper.

(c) These mechanisms may in some cases be corrected via spin-echo techniques or suppressed by freezing out the background spins.

(6) Other mechanisms for longitudinal spin relaxation,  $T_1$ , such as hyperfine coupling to Si (Ref. 29) nuclei in natural Si,  $1/f$  noise, and Johnson noise, are normally small in

the parameter ranges considered here, though further work is required to verify this.<sup>28</sup> The magnetic field dependence of these effects allows them to be easily distinguished from spin-phonon coupling, as we show below.

(7) The phonon-bottleneck effect operates rather weakly in the parameter regime of interest for quantum dot applications. It can be calculated in a theory that goes beyond the ED approximation; the result is only a slight enhancement of  $T_1$  in parameter regimes typical for possible quantum computer operation.

(8) Orbital relaxation in strained silicon is much faster than in bulk silicon in some important cases.<sup>3</sup> Surprisingly, the rate of spontaneous decay from the first excited orbital state in silicon quantum dots can be comparable to that of GaAs quantum dots, which are commonly expected to relax more efficiently due to that crystal's piezoelectric nature. This has important implications for optically induced motional spin-charge transduction (readout) and optical pumping (initialization) of spin qubits,<sup>29</sup> making the former harder and the latter easier, as well as for excited-state spectroscopy.

(9) Excited valley state relaxation can be slow in silicon due to a small matrix element connecting valley states of different symmetries; this leads to the hope of valley qubits.<sup>4,30–32</sup> The phonon emission rate has a maximum at the Umklapp phonon energy (11 and 23 meV for transverse and longitudinal phonons in silicon) that connects valley minima from one Brillouin zone to its nearest neighbor.<sup>13</sup> This leads to nanosecond relaxation times<sup>33</sup> in P donors with their large valley splitting ( $\sim 10$  meV), but in quantum dots this is suppressed due to a large energy mismatch. However, the valley index, in general, cannot be considered a good quantum number in quantum dots due to large valley-orbit mixing.<sup>34</sup> Thus, “valley relaxation” in realistic devices can be dominated by fast orbital relaxation due to mixing with nearby orbital levels. The situation is different and more favorable in some cases such as for Li donors or P in strained silicon with their smaller valley splittings.<sup>4,33</sup>

(10) Nonideal interfaces in silicon quantum dots may effect the relaxation processes; these effects are microscopic in origin<sup>34–36</sup> with potentially significant implications on relaxation in some cases. We do not consider this situation quantitatively in this paper.

### III. SILICON QUANTUM DOT STATES

This work is concerned mainly with lateral quantum dots formed by heterostructure confinement in the growth ( $z$ ) direction and lateral confinement by metallic top gates. Figure 1 shows some of the heterostructure choices possible in constructing these dots, from modulation doped 2D electron gas (2DEG) structures depleted by top gates to accumulation-mode inversion-layer devices in metal-oxide-semiconductor field-effect transistor (MOSFET)-like structures. We concern ourselves here predominately with the SiGe quantum well (QW) QD case, although our considerations should carry over to Si MOSFET dot structures as well.

In semiconductors, the electron wave functions are superpositions of Bloch states at the bottom of the conduction band (CB), so the indirect band-gap, “many-valley” nature of silicon (as opposed to a single  $\Gamma$  valley in GaAs) takes on great importance. In a biaxially strained silicon QW, the number of states is doubled relative to GaAs, but reduced from the sixfold degeneracy of electrons in the bulk. The CB minima located at  $\mathbf{k} = (0, 0, \pm k_0)$  with  $k_0 = 0.85k_{\text{max}}$  have band energies lower than the minima at  $\mathbf{k} = (\pm k_0, 0, 0)$  and  $\mathbf{k} = (0, \pm k_0, 0)$  by about 0.1 to 0.15 eV at typical strain values (20%–30% Ge in the barriers).<sup>37</sup> Thus, the  $\mathbf{k} = (0, 0, \pm k_0)$  valleys are populated but not the  $\mathbf{k} = (0, \pm k_0, 0)$  and  $\mathbf{k} = (\pm k_0, 0, 0)$  valleys.<sup>38</sup> A similar (quite large) splitting is at work in Si MOSFET-type structures, though here the physical origin of the lifting of the degeneracy is due to anisotropy of the silicon effective mass (and in some cases local strain).<sup>35</sup> In the absence of magnetic fields and valley-splitting effects, the electronic ground state

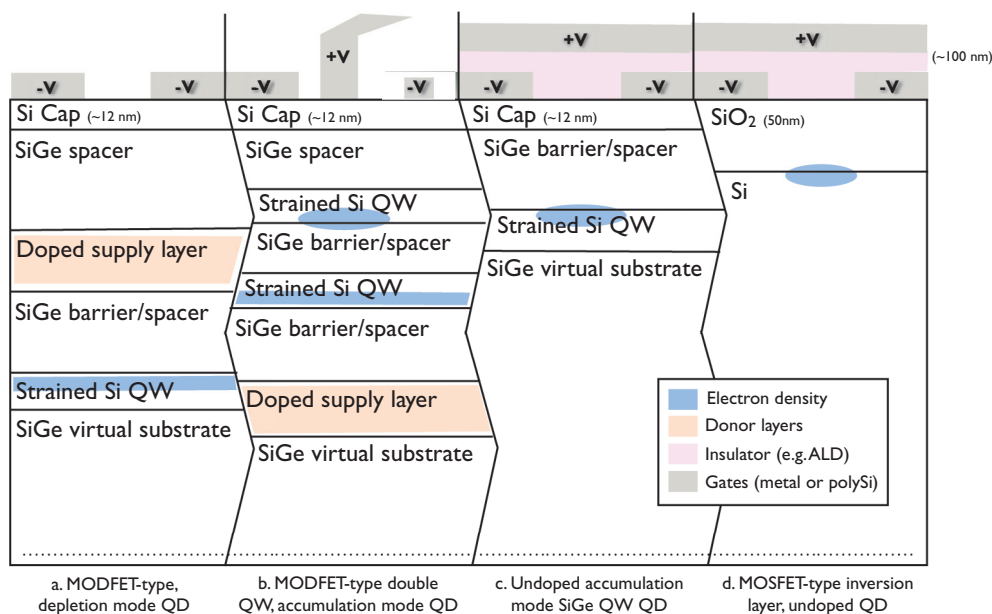


FIG. 1. (Color online) Different types of quantum dot heterostructures relevant to the theory in this paper.

in this system is fourfold degenerate (spin and valley). When potentials or boundary conditions that mix the two valleys are present, as they always will be to some extent, there will be excited valley states corresponding to different linear combinations of the valley minima. So each valley state has its own identical set of orbital and spin states and an additional quantum number is needed to specify which valley state the electron occupies.

A magnetic field splits the degeneracy of the spin states. The valley degeneracy is split by the hard confinement of the QW interfaces (or the impurity potential in that case) and is influenced by a number of parameters, especially the magnitude of the electric field in the growth direction and the sharpness of the confining potential. For the moment, we assume for simplicity that any static magnetic field is small or directed in the plane of the QW (so that the orbital functions are unperturbed) and that the well walls, located at  $z = \{0, d\}$ , are smooth. In these circumstances, we may write

$$\psi_m^{(i)} = F_m^{(i)}(x, y) F_m^{(i)}(z) [\alpha_{+z}^{(i)} u_{+z}(\mathbf{r}) e^{ik_z z} + \alpha_{-z}^{(i)} u_{-z}(\mathbf{r}) e^{-ik_z z}],$$

$F_m^{(i)}(z)$  is the envelope function obtained by solving the confinement problem in the effective mass approximation for the  $m$ th orbital,  $\alpha_{\pm z}^{(i)}$  are the coefficients weighting the two valleys for the  $i$ th valley state ( $i = 1, 2$  for strained silicon,  $i = 1, 2, 3, 4, 5, 6$  for bulk silicon), and  $u_{\pm z}(\mathbf{r})$  are the lattice-periodic parts of the Bloch functions,  $u_j(\mathbf{r}) \exp(i\mathbf{k}_j \cdot \mathbf{r})$ , at the CB minimum  $\mathbf{k}_j$ .  $\alpha_z^{(i=+)} = \alpha_{-z}^{(+)} = 1/\sqrt{2}$  for the symmetric valley (“sinelike”) state and  $\alpha_z^{(i=-)} = -\alpha_{-z}^{(-)} = 1/\sqrt{2}$  for the antisymmetric valley (“cosinelike”) state. It is often convenient to expand the Bloch functions into a sum,

$$u(\mathbf{r}) = \sum_{\mathbf{G}} C_{\mathbf{G}} \exp[i\mathbf{r} \cdot \mathbf{G}],$$

where  $C_{\mathbf{G}}$  weight the Fourier components of expansion (independent of  $\mathbf{r}$ ) and  $\mathbf{G}$  are the reciprocal lattice vectors. The wave functions for a more realistic device, calculated in the tight-binding theory of Ref. 39, are shown in Fig. 8 (where the “Kohn-Luttinger” oscillations are evident but the lattice-periodic oscillations are not included). A donor vs dot energy level comparison is shown in Fig. 2.

Until now we have only concerned ourselves with “perfect” (completely flat) interfaces. In these cases the valley and orbital states are well defined—valley index being a generally good quantum number—much like the isolated donor case. In reality, most interfaces are imperfect; they have alloy disorder (Si vs Ge atoms), steps due to miscut, steps due to growth layer formation, and even interface states and traps (especially with respect to Si/SiO<sub>2</sub> interfaces). This leads to mixing of the valley and orbital wave functions as well as diminishing of the valley splitting (due to interference),<sup>34,36</sup> and as such, wave functions and splittings that vary from device to device and dot to dot. These microscopic variations are not considered in this paper. Fortunately, these effects are often not large corrections to the calculations below, as the experimentally accessible energy splittings come into the equations at a much higher power than the relevant (experimentally inaccessible) matrix elements. As we go we point out differences from our theory for the ideal and likely situations, focusing on experimentally accessible signatures.

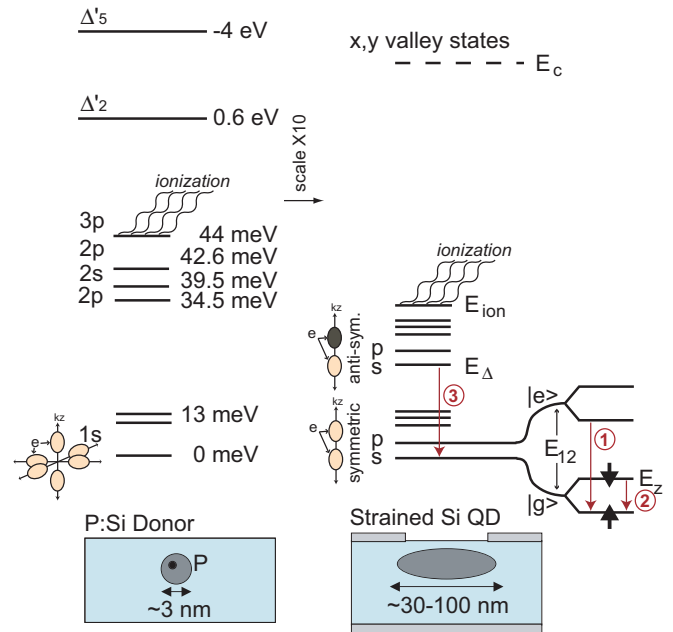


FIG. 2. (Color online) Energy level diagram for P donors in Si (left) and Si quantum dots (right). Note the reduction in energy scale from left to right. In both cases, the electron exists as a superposition of different conduction valley minima within the crystal. Different low-lying dot levels (all  $s$ -like) result from the sharp donor potential and different amplitudes in the six valleys shown. Low-lying dot states arise from different orbital wave functions with a further valley splitting (far right) between symmetric and antisymmetric combinations of the two valleys,  $\pm z$ . The circled numbers represent relevant relaxation processes: (1) orbital relaxation across the first energy gap; (2) spin relaxation of the electron qubit; and (3) valley relaxation. Note that the valley splitting can vary from 0 to meV and may fall within the energy levels of the low-lying Zeeman and orbital states.

#### IV. ELECTRON-PHONON INTERACTION

Phonons are quanta of lattice vibrations, that is, mechanical motion that gives time-dependent stress. This alters the band structure by shifting band energies and lifting degeneracies.<sup>38,40</sup> It is typically assumed that this effect does not change the band curvature (effective masses) but does shift the energy states of interest. The shift in energy of the band edge per unit elastic strain is called the *deformation potential* and is common to all semiconductors and solids. In polar crystals, distortion of the lattice can also create large internal electric fields which affect the electron. This is the piezoelectric interaction. Ionic crystals like GaAs suffer from piezophonons, which are often very efficient at electron scattering; silicon, being nonpolar and centrosymmetric, has none. While optical strain also exists in materials with two atoms per unit cell, such as silicon, optical phonons in silicon have a narrow bandwidth centered at a much higher energy than a quantum computer would operate. We briefly review the theory of the electron-phonon deformation potential interaction outlined by Herring and Vogt.<sup>41</sup>

The energy shift of a nondegenerate band edge due to strain is given by

$$H_{eL} = \sum_{\alpha,\beta} U_{\alpha\beta} \Xi_{\alpha\beta}^{(i)}, \quad (1)$$

where

$$U_{\alpha\beta} = \frac{1}{2} \left( \frac{\partial u_i}{\partial x_i} + \frac{\partial u_j}{\partial x_i} \right)$$

is the strain tensor and  $\Xi^{(i)}$  is the deformation potential tensor for the  $i$ th silicon CB valley. Since our electron is confined to massively strained [001] silicon, we need only include the  $(0,0,\pm k_0)$  valleys which have deformation potential tensors given by

$$\Xi^{\pm z} = \Xi_d \delta_{\alpha\beta} + \Xi_u K_\alpha^{(i)} K_\beta^{(i)} = \begin{pmatrix} \Xi_d & 0 & 0 \\ 0 & \Xi_d & 0 \\ 0 & 0 & \Xi_d + \Xi_u \end{pmatrix}, \quad (2)$$

where  $\Xi_d$  relates to pure dilatation and  $\Xi_u$  is associated with shear strains.  $\hat{\mathbf{K}}^{(i)}$  is a unit vector in the direction of the  $i$ th valley. For silicon under compressive stress along [001], opposing valleys move in energy identically. In order to associate phonon modes with strain, we can expand the unit cell displacement  $\mathbf{u}(\mathbf{r})$  in plane waves,  $\mathbf{u}(\mathbf{r}) = \sum_{\mathbf{q},\lambda} [\mathbf{e}(\mathbf{q},\lambda) a_{\mathbf{q}\lambda} e^{i\mathbf{q}\cdot\mathbf{r}} + \mathbf{e}^*(\mathbf{q},\lambda) a_{\mathbf{q}\lambda}^* e^{-i\mathbf{q}\cdot\mathbf{r}}]$ .  $a_{\mathbf{q}\lambda}$  destroys a phonon with wave vector  $\mathbf{q}$  and polarization  $\lambda$  (two transverse and one longitudinal; see details in Table II) of a phonon;  $\mathbf{e}(\mathbf{q},\lambda)$  is its unit displacement vector. This results in a strain tensor due to a phonon of

$$U(\mathbf{q},\lambda)_{\alpha\beta} = \frac{i}{2} \{ [\mathbf{e}_\alpha(\mathbf{q},\lambda) q_\beta + \mathbf{e}_\beta(\mathbf{q},\lambda) q_\alpha] a_{\mathbf{q}\lambda}^* e^{-i\mathbf{q}\cdot\mathbf{r}} + [\mathbf{e}_\alpha(\mathbf{q},\lambda) q_\beta + \mathbf{e}_\beta(\mathbf{q},\lambda) q_\alpha] a_{\mathbf{q}\lambda} e^{i\mathbf{q}\cdot\mathbf{r}} \}. \quad (3)$$

The operators  $a_{\mathbf{q}\lambda}$  and  $a_{\mathbf{q}\lambda}^*$  have matrix elements,  $\langle n_{\mathbf{q}\lambda} - 1 | a_{\mathbf{q}\lambda} | n_{\mathbf{q}\lambda} \rangle = \sqrt{\hbar n_{\mathbf{q}\lambda} / 2M_c \omega_{\mathbf{q}\lambda}}$  and  $\langle n_{\mathbf{q}\lambda} + 1 | a_{\mathbf{q}\lambda}^* | n_{\mathbf{q}\lambda} \rangle = \sqrt{\hbar(n_{\mathbf{q}\lambda} + 1) / 2M_c \omega_{\mathbf{q}\lambda}}$ ,  $M_c$  is the mass of the crystal, and  $n_{\mathbf{q}\lambda} = 1 / (e^{\hbar\omega_{\mathbf{q}\lambda} / kT} - 1)$  is the phonon occupation number of the mode with wave number  $\mathbf{q}$  and polarization  $\lambda$ . The complete electron-phonon Hamiltonian must be summed over phonon modes and polarizations. For a [001] strained-silicon quantum well, it can be written succinctly as

$$H_{ep} = \sum_{\lambda=1}^3 \sum_{\mathbf{q}} i\mathbf{q} [a_{\mathbf{q}\lambda}^* e^{-i\mathbf{q}\cdot\mathbf{r}} + a_{\mathbf{q}\lambda} e^{i\mathbf{q}\cdot\mathbf{r}}] \times [\Xi_d \mathbf{e}_x(\mathbf{q},\lambda) \hat{q}_x + \Xi_d \mathbf{e}_y(\mathbf{q},\lambda) \hat{q}_y + (\Xi_d + \Xi_u) \mathbf{e}_z(\mathbf{q},\lambda) \hat{q}_z]. \quad (4)$$

We are especially concerned with the anisotropic effects due to the massive strain of the system in question. As can be seen from Eq. (2) and the deformation constant values in Table I, the shift in energy of a specific valley due to an acoustic phonon is very anisotropic. In the case of bulk Si, the six CB minima are equidistant from the  $\Gamma$  point and thus form an isotropic response to phonon deformations. This means essentially that transverse phonons will not contribute to the relaxation times for intervalley transitions of the same

TABLE I. Physical constants and materials parameters for bulk silicon.

Constant	Value
$\epsilon_0$	$8.85 \times 10^{-12} \text{ C}^2/\text{Nm}^2$
$\epsilon_{\text{Si}}$	11.8
$g_{\parallel}(\text{Si})$	1.999
$g_{\perp}(\text{Si})$	1.998
$m_i$	$0.19m_0$
$\Xi_u(\text{Si})$	$8.77 \text{ eV} = 1.4 \times 10^{-18} \text{ J}$
$\Xi_d(\text{Si})$	$5 \text{ eV} = 8 \times 10^{-19} \text{ J}$
$\rho(\text{Si})$	$2330 \text{ kg/m}^3$
$v_t(\text{Si})$	$9330 \text{ m/s}$
$v_l(\text{Si})$	$5420 \text{ m/s}$
$a_0(\text{Si})$	$0.357 \text{ nm}$
$k_{\text{max}}(\text{Si})$	$2\pi/a_0$

symmetry (that is,  $\alpha_n^{(i)} = \alpha_n^{(j)}$  for initial state  $i$  and final state  $j$ ). Another way to see this is to consider the electron-lattice matrix element between different plane-wave states at the same minimum [Eq. (3.29) of Ref. 11],  $\langle \psi_m^{(i)} | H_{eL} | \psi_n^{(j)} \rangle_{\mathbf{q}t} = a_{\mathbf{q}t} [i\mathbf{e}(\mathbf{q},t) \cdot \Xi^{(i)} \cdot \mathbf{q}] f_{mn}^{(i)}(\mathbf{q}) + \text{c.c.}$ , where  $f_{mn}^{(i)}(\mathbf{q}) = \int F_m^{(i)}(\mathbf{r}) e^{i\mathbf{q}\cdot\mathbf{r}} F_n^{(i)} d\mathbf{r}$ . We have used the polarization index  $t$  to indicate a transverse phonon. The matrix element between two dot wave functions is then  $\langle \sum \alpha_m^{(i)} \psi_m^{(i)} | H_{eL} | \sum \alpha_n^{(j)} \psi_n^{(j)} \rangle_{\mathbf{q}t} = a_{\mathbf{q}t} [i\mathbf{e}(\mathbf{q},t) \cdot \sum \alpha_m^{(i)} \alpha_n^{(j)} \Xi^{(i)} \cdot \mathbf{q}] f_{mn}^{(i)}(\mathbf{q}) + \text{c.c.}$  It is easy to see from the above equation that if  $\sum \alpha_m^{(i)} \alpha_n^{(j)} \Xi^{(i)}$  is proportional to the identity matrix (assuming  $\alpha_m = \alpha_n = 1$ ), then the transverse phonon matrix elements must be zero since  $\mathbf{e}_{t1}(\mathbf{q},t1) \perp \mathbf{e}_{t2}(\mathbf{q},t2) \perp \mathbf{q}$ . The point is that in strained silicon, only the  $\pm z$  minima are occupied, so unlike the bulk silicon case, transverse phonons will contribute. This turns out to be very important in relaxation calculations, as seen below.

## V. ORBITAL RELAXATION IN STRAINED SI QUANTUM DOTS

We consider first the relaxation of an excited state that involves no spin flip or valley state change (assuming for now no valley-orbit mixing). Spontaneous emission of a single acoustic phonon is the dominant relaxation mechanism for excited electronic states in Si at QC temperatures ( $< 100 \text{ mK}$ ) for Si donor states<sup>6,42</sup> and GaAs quantum dots.<sup>43</sup> The deformation potential approach<sup>41</sup> is easily modified to include strain.<sup>16</sup> The results for strained silicon are quite different from those of bulk silicon,<sup>8</sup> since the response of the occupied valleys to phonon deformations is not isotropic and the angular integral over transverse phonons does not average to zero. For example, the transition from the ground,  $1s$ -like symmetric state to the  $2p$ -like, symmetric state in bulk silicon has no transverse phonon contribution.<sup>8</sup> The same transition in strained silicon does have such a contribution, because the cubic symmetry of the six minima has been broken by strain: In fact, it is the largest term. This greatly increases the relaxation rate since the inverse sound velocity comes into the rate equations with a very high power as we now show.

Fermi's golden rule, between states of arbitrary spin,

$$\Gamma = \frac{2\pi}{\hbar} |\langle nsv | H_{ep} | ms'v' \rangle|^2 \delta(E_{ph} - E_{ns,ms'}), \quad (5)$$

is the basis for our phonon relaxation rate calculations. Here,  $|nsv\rangle$  is the state  $\psi_{ns}^{(v)}$  of the electron in the dot on level  $n$  with spin state  $s$  and on valley manifold  $v$ , including the effect of a magnetic field. We assume an isotropic phonon spectrum such that the energy of the phonon is  $E_{ph} = \hbar\omega_{\mathbf{q}\lambda}$ , where  $\omega_{\mathbf{q}\lambda} = v_\lambda |\mathbf{q}|$  and  $v_\lambda$  is the velocity of the mode  $\lambda$ . Setting  $s = s'$  for orbital relaxation without a spin flip and  $v = v'$ ,  $E_{ns,ms'} = E_{mn}$  is the energy splitting between states  $m$  and  $n$  and  $H_{ep}$  is the electron-phonon interaction of Eq. (4). Summing over phonon modes, using  $\hat{q} = (\sin\theta \cos\phi, \sin\theta \sin\phi, \cos\theta)$  and  $\hat{e}_l = \hat{q} \perp \hat{e}_{l1} \perp \hat{e}_{l2}$  for the wave vector and polarization vectors and using the ED approximation,  $e^{i\mathbf{q}\cdot\mathbf{r}} \approx 1 + i\mathbf{q}\cdot\mathbf{r}$ , we find for the phonon-induced relaxation rate,

$$\Gamma_{mn}^{ED} = \frac{|E_{mn}|^5}{\hbar^6 \pi \rho_{\text{Si}}} \{ (|M_x^{(mn)}|^2 + |M_y^{(mn)}|^2) \Upsilon_{xy} + |M_z^{(mn)}|^2 \Upsilon_z \} \times [n_B(E_{mn}) + 1], \quad (6)$$

where

$$\begin{aligned} \Upsilon_{xy} &= \frac{35 \Xi_d^2 + 14 \Xi_d \Xi_u + 3 \Xi_u^2}{210 v_l^7} + \frac{2 \Xi_u^2}{105 v_l^7}, \\ \Upsilon_z &= \frac{35 \Xi_d^2 + 42 \Xi_d \Xi_u + 15 \Xi_u^2}{210 v_l^7} + \frac{\Xi_u^2}{35 v_l^7}, \end{aligned} \quad (7)$$

the matrix elements are  $\vec{M}^{(mn)} = \langle F_m | \vec{r} | F_n \rangle$ ,  $\rho_{\text{Si}}$  is the mass density of Si,  $E_{mn}$  is the energy gap between orbital states, and  $v_\ell$  and  $v_t$  are the longitudinal and transverse sound velocities, respectively. The single-electron envelope functions can be calculated by solving the Poisson and Schrödinger equations directly as in Ref. 1 or, as is normally done, by approximating the potential as a parabola, giving harmonic oscillator states defined by the fundamental energies  $E_{10} = \hbar\omega_{x,y}$ . With the envelope functions  $F_0 = (2/\pi)^{1/4} x_0^{-1/2} \exp(-x^2/x_0^2)$  and  $F_1 = (2/\pi)^{1/4} (2/\sqrt{x_0^3}) x \exp(-x^2/x_0^2)$ , the matrix element is given by

$$|M_x^{(10)}|^2 = \frac{\hbar^2}{m_t E_{10}} = \left( \frac{x_0}{2} \right)^2, \quad (8)$$

where  $2\sqrt{\langle x^2 \rangle} = \max\{x_0, y_0\} = \sqrt{2\hbar/\sqrt{m_t E_{10}}}$  is the lateral size of the dot,  $L$ ,  $x_0$  and  $y_0$  are the dot sizes in the  $x$  and  $y$  directions, respectively, and  $m_t$  is the transverse mass of the electron. We define  $E_{10} \equiv E_1 - E_0$ . Thus, the orbital relaxation rate from the lowest orbital state for a slightly asymmetric (nondegenerate excited state), parabolic dot is

$$\Gamma_{10}^{ED} = \frac{2 \Xi_u^2}{105 v_l^7} \frac{E_{10}^4}{\hbar^4 \pi \rho_{\text{Si}} m_t} [n_B(E_{10}) + 1] \quad (9)$$

(we have used the fact that  $v_l \sim 2v_t$  to eliminate terms due to longitudinal phonons). Because  $E_{mn}$  appears in the fifth power (general case) or fourth power (parabolic dots) in Eqs. (6) and (9) for orbital relaxation, an accurate value for  $E_{mn}$  is much more important than equivalent accuracy in the wavefunction matrix elements. The dipole approximation is valid

TABLE II. Characteristic numbers for the phonon-bottleneck effect in Si and orbital relaxation rates.  $\Delta$  is the first excitation energy,  $L$  is the lateral dimension, and  $\lambda$  is the wavelength of the transverse phonon with the resonant energy.

$E_{10}$ (meV)	$L$ (nm)-Si	$\lambda$ (nm)-Si( $v_t$ )	$1/\Gamma_{ED}$ [Eq. (6)]	$1/\Gamma_{\text{exact}}$ [Eq. (10)]
0.05	127	447	$2.5 \times 10^{-7}$ s	$4.0 \times 10^{-7}$ s
0.1	90	223	$1.6 \times 10^{-8}$ s	$3.8 \times 10^{-8}$ s
0.2	63	112	$9.7 \times 10^{-10}$ s	$5 \times 10^{-9}$ s
0.3	52	75	$1.9 \times 10^{-10}$ s	$1.8 \times 10^{-9}$ s
0.4	45	56	$6.0 \times 10^{-11}$ s	$9.5 \times 10^{-10}$ s
0.5	40	47	$2.5 \times 10^{-11}$ s	$6 \times 10^{-10}$ s
1	28	22	$1.6 \times 10^{-12}$ s	$1.4 \times 10^{-10}$ s
2	20	11	$9.7 \times 10^{-14}$ s	$3.8 \times 10^{-11}$ s
3	16	7.4	$1.9 \times 10^{-14}$ s	$1.9 \times 10^{-11}$ s
8	10	2.8	$3.8 \times 10^{-16}$ s	$9.6 \times 10^{-12}$ s
10	9	2.2	$1.6 \times 10^{-16}$ s	$1.4 \times 10^{-11}$ s

until roughly  $qL \gg 1$  ( $L$  is the maximal linear size of the dot) when the relaxation rate starts to decrease due to phonon-bottleneck effects. We treat this effect explicitly in the next section.

## VI. PHONON-BOTTLENECK EFFECT

When the dot becomes very small ( $L$  comparable to a few interatomic spacings), the relaxation rate is reduced. This is due to the impossibility of satisfying simultaneously energy and momentum conservation during an electron-acoustic-phonon scattering event.<sup>44</sup> Mathematically, the phonon-bottleneck effect is due to the fast oscillating exponential factor: Emission of a phonon with wave vector  $\mathbf{q}$  is unlikely when  $q > 2\pi/L$  (Ref. 45). Table II charts this transition for parabolic Si quantum dots. Note that in a lateral quantum dot, unlike excitonic quantum dots, Auger processes and electron-hole scattering do not play a role in negating phonon bottleneck. Assuming parabolic dots, only dots with fundamental energies  $\Delta \approx 1\text{--}2$  meV are small enough (and virtually impossible to construct with laterally gated devices) for phonon-bottleneck effects to make a significant impact on increasing the orbital relaxation times.

We outline the calculation for Si, including the valley effects, in the Appendix. The chief difficulty is to include all multipole moments. The result is that the orbital relaxation rate for a parabolic dot (in all three dimensions) from its first orbital, excited state to its ground state is given by

$$\begin{aligned} \Gamma_{10}^{\text{exact}} &= [n_B(E_{10}) + 1] \frac{\hbar E_{10}^4}{16\pi \rho_{\text{Si}} m_t} \\ &\times \left\{ \exp\left(-\frac{1}{4} x_0^2 q_{\Delta l}^2\right) \frac{1}{\hbar^5 v_l^7} [\Xi_d^2 (A_l^{(0)} - A_l^{(2)}) \right. \\ &+ 2 \Xi_d \Xi_u (A_l^{(2)} - A_l^{(4)}) + \Xi_u^2 (A_l^{(4)} - A_l^{(6)})] \\ &\left. + \exp\left(-\frac{1}{4} x_0^2 q_{\Delta t}^2\right) \frac{1}{\hbar^5 v_l^7} \Xi_u^2 [A_t^{(2)} - 2A_t^{(4)} + A_t^{(6)}] \right\}, \end{aligned} \quad (10)$$

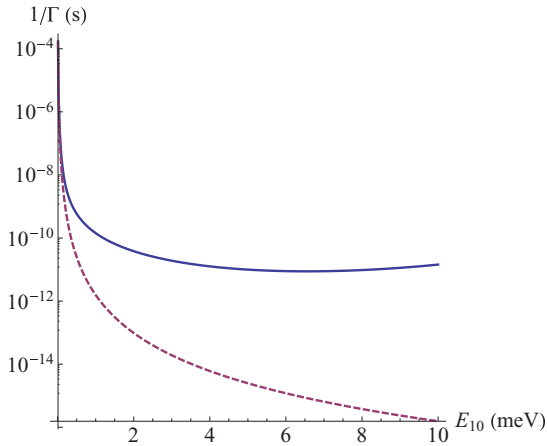


FIG. 3. (Color online) Relaxation rates,  $1/\Gamma$ , for the transition from the first excited orbital state to the ground state by emission of a phonon versus orbital energy splitting,  $\Delta$ . The exact results including all multipole contributions are given by the blue solid line while the ED approximation results are given by the purple dashed line.

where  $z_0$  is the size of wave function in the growth direction and  $q_{\Delta l} = \Delta/\hbar v_l$ ,  $q_{\Delta t} = \Delta/\hbar v_t$ . The  $A$  coefficients are defined by

$$A_s^{(n)}(q_{\Delta s}) = \int_1^{-1} x^n \exp\left[\frac{1}{4}(x_0^2 - z_0^2)q_{\Delta s}^2 x^2\right].$$

The results are plotted in Fig. 3. Note that the exact expression [Eq. (10)] reduces to the dipole approximate expression [Eq. (6)], when  $q_{\Delta}^2 = 0$  as expected. For large  $E_{10}$ , the exact solution for the orbital relaxation rate  $\Gamma_{10}$  begins to diverge from the ED approximation early on and never falls below a picosecond or so. Despite this, the ED approximation holds well for small energy gaps, 0.1–2 meV, where a quantum computer in silicon will most likely operate. This figure shows that there is no significant benefit in going beyond a few meV. Only around 10 meV does the relaxation time start to increase, but this is a relatively small effect. It does demonstrate, however, that the phonon-bottleneck effect may be experimentally observable in these systems and, more importantly, that our use of the ED approximation gives results below for the spin-flip times that may be considered a lower bound on the maximum possible time  $T_1$ .

Table II compares the output of Eqs. (6) and (10) for pure orbital relaxation in lateral silicon quantum dots. Note that the full solution is required once  $E_{10} > 0.1$  meV. One can compare these results to those for GaAs quantum dots,<sup>46</sup> where typical values would be  $1/\Gamma = 10^{-8}$  s for  $E_{10} = 1$  meV and piezophonons dominate. Excited orbital states in strained silicon typically relax in nanoseconds or faster, corresponding to a level broadening of a micro-eV or wider. It is possible that a low-lying excited valley state (of the same spin direction) may be closer in energy than the orbital level. For bulk silicon, theory and experiment have found characteristic relaxation times for the  $2p$ - $1s$  transition of  $\sim 200$  ps.<sup>47</sup>

## VII. SPIN-FLIP ( $T_1$ ) TIMES

Our expressions for orbital relaxation in strained silicon can be extended to the case of a spin-flip transition due

to SOC in a QW. We expect that relaxation via a phonon is the dominant cooling mechanism, in this case mediated by SOC which mixes pure spin states. This is known to be the case for donor-bound spins in bulk.<sup>6</sup> Structural inversion asymmetry has traditionally been thought to be the dominant source of SOC in silicon quantum wells due to the large electric field common to modulation-doped or top-gated SiGe heterostructures. The nature of this SOC has been well described elsewhere;<sup>21,24–26,48</sup> it leads to a Rashba term in the Hamiltonian of the electrons. However, interface effects that break the inversion asymmetry can also lead to a generalized Dresselhaus-like term.<sup>25</sup> Surprisingly, this can lead to effects of similar or even greater magnitude than the Rashba term.<sup>24–26</sup> We discuss this further below. Here we only note that the zero-field energy level splittings caused by SOC are small, of the order of  $\mu\text{eV}$ , which validates our use of a perturbation theory that uses zero-order electron wave functions and energy levels taken from the SOC-free Hamiltonians.

Until the appearance of Refs. 3 and 29, there was no finite spin-flip time prediction for lateral silicon quantum dots when the external field  $\vec{B}$  is parallel to  $\hat{z}$ . Previous theories for  $T_1$  in silicon had been based on the two dominant mechanisms relevant to P:Si donors: the valley-repopulation mechanism (bulk SOC mixing with the six nearby  $1s$ -like states) and the one-valley mechanism (bulk SOC mixing with continuum states).<sup>9–11</sup> Both mechanisms are independent of the size and shape of the localized electron wave function. We showed rigorously in Ref. 16 that the former becomes negligible with [001] strain. The latter is slightly modified with strain and goes to zero for certain directions of the static magnetic field, particularly the [001] direction (the most relevant to QC), for both one and two-phonon processes.<sup>17</sup> We review these bulk mechanisms here as they are relevant for donor qubits and in some cases may be seen as residual  $T_1$  mechanisms at low magnetic fields in dots. Then we derive the spin-relaxation times for dots in strained structures due to inversion asymmetry-based SOC leading to a  $T_1$  that is finite for  $\vec{B}$  parallel to  $\hat{z}$ .

### A. Bulk spin-flip mechanisms

For donor states in bulk silicon, Roth and Hasegawa<sup>9–11</sup> identified two mechanisms that have been confirmed experimentally up to  $T = 2$  K in P donor spins.<sup>12</sup> The spin relaxation in the Roth-Hasegawa picture is due to a modulation of the system's  $g$  factor by acoustic phonons. Both mechanisms are direct single-phonon processes. The  $g$  tensors for a given CB state can be written as a sum over the  $g$  tensors at each CB minimum,

$$\mathbf{g} = \sum_i \alpha_i \mathbf{g}_i,$$

where  $|\alpha_i|^2$  is the squared amplitude (“population” in the early literature) of the single-electron wave function at the  $i$ th valley and  $\mathbf{g}^{(i)} = g_{\perp} \delta_{\alpha\beta} + (g_{\parallel} - g_{\perp}) K_{\alpha}^{(i)} K_{\beta}^{(i)}$ .

There are two mechanisms leading to spin flip. The valley-repopulation mechanism is due to mixing between the symmetric ground state of the donor electron and the split-off doublet state where a phonon changes the  $\alpha_i$ 's. The one-valley mechanism is due to phonon-induced modulation of the  $\mathbf{g}_i$  themselves and subsequent mixing with nearby CBs, which

are coupled through an interband deformation potential. The two mechanisms are of the same order of magnitude in the bulk case and complementarily explain the angular magnetic field dependence of  $T_1$  in those systems.<sup>12</sup>

Reference 16 showed how the valley-repopulation contribution to the spin flip becomes negligible with increasing [001] compressive strain, as is inherent in a silicon quantum dot. This can be seen easily qualitatively. Consider first a potential with spherical symmetry. The population amplitudes describing the lowest six conduction states are given by<sup>12</sup>

$$\begin{aligned} \text{singlet: } \alpha_{11} &= \frac{1}{\sqrt{6}}(1, 1, 1, 1, 1, 1); \\ \text{doublet: } \alpha_{21} &= \frac{1}{\sqrt{12}}(-1, -1, -1, -1, 2, 2), \\ \alpha_{22} &= \frac{1}{\sqrt{4}}(1, 1, -1, -1, 0, 0); \\ \text{triplet: } \alpha_{31} &= \frac{1}{\sqrt{2}}(1, -1, 0, 0, 0, 0), \\ \alpha_{32} &= \frac{1}{\sqrt{2}}(0, 0, 1, -1, 0, 0), \\ \alpha_{33} &= \frac{1}{\sqrt{2}}(0, 0, 0, 0, 1, -1), \end{aligned}$$

in the valley basis ( $x, -x, y, -y, z, -z$ ). The six states are split even at zero strain by nonspherical central-cell corrections in the donor case (the sharp potential of the donor) and by the interfaces in the quantum dot case. SOC represented by the anisotropic  $g$  factor mixes the singlet ground state only with one of the doublet states.<sup>16</sup> In QDs the strong compressive strain in the  $z$  direction causes a large relative splitting between the six valley states; the result is that only the  $\alpha_{11}$  and the  $\alpha_{33}$  states will be populated. These symmetric and antisymmetric valley states are not mixed by the SOC which results in a vanishing matrix element. So, in the quantum dot limit ( $\pm z$  valleys populated), the valley-repopulation contribution to the spin-flip rate becomes negligible. Note that for this mechanism we only consider mixing to the six lowest states of the donor, all of which have orbital  $s$ -like character. The  $2p$  states in a donor are typically 30 meV (bulk) to 3 meV ([001] strain) away. Mixing with these states is considered separately below.

The one-valley mechanism, however, is relevant to QDs. Roth showed that in bulk silicon, the contribution from mixing with nearby bands is described by a Hamiltonian,

$$H_{\text{one-valley}}^{\text{bulk}} = A\beta[U_{xy}(\sigma_x B_y + \sigma_y B_x) + \text{c.p.}],$$

where c.p. stands for cyclic permutations.  $B_x$ ,  $B_y$ , and  $B_z$  are the Cartesian components of the external magnetic field.  $\beta$  is the Bohr magneton. Group theoretical considerations and perturbation theory lead to the conclusion that the dominant contribution to  $A$  comes from mixing with the nearby  $\Delta'_2$  and  $\Delta_5$  bands and is given by

$$\begin{aligned} A &= \frac{2i\beta}{3m_t} \frac{\langle \Delta_2 | p_z | \Delta_2 \rangle \langle \Delta_2 | D_{xy} | \Delta_1 \rangle}{E_{12}^2 E_{15}} \\ &\times \left\{ \langle \Delta_1 | p_x | \Delta_5^x \rangle \langle \Delta_5^x | h_x | \Delta_2 \rangle + \langle \Delta_1 | h_x | \Delta_5^y \rangle \langle \Delta_5^y | p_x | \Delta_2 \rangle \right\} \\ &\times \Delta g_{\perp} \frac{E_{15}}{E_{12}^2} \langle \Delta_2 | D_{xy} | \Delta_1 \rangle, \end{aligned}$$

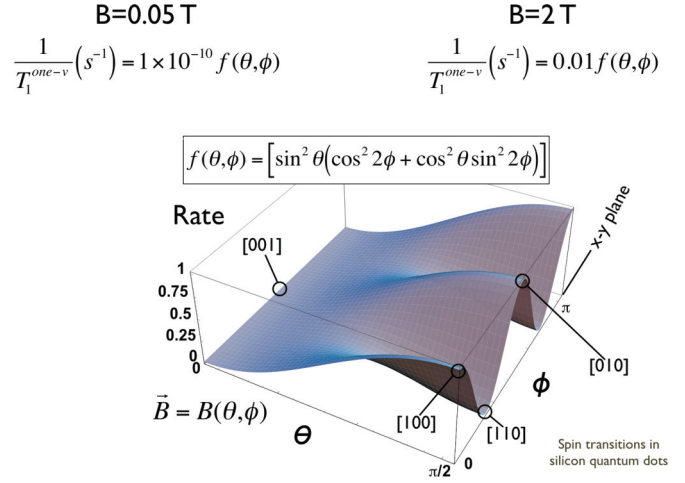


FIG. 4. (Color online) Dependence of the spin-relaxation rate on the angle of the external magnetic field for the one-valley mechanism in strained-silicon quantum dots (or donors in strained silicon).

where  $\mathbf{h} = \nabla V \times \mathbf{p}$  is the usual crystal spin-orbit vector,  $\mathbf{p}$  is the momentum operator,  $E_{ij}$  are the energy gaps to the relevant bands, and  $D$  is the interband deformation potential.  $H_{\text{one-valley}}^{\text{bulk}}$  represents a sum over the six minima in the bulk case, but in a lateral quantum dot the dominant contribution comes only from the  $\pm z$  minima and was determined by Glavin and Kim<sup>17</sup> to be

$$H_{\text{one-valley}}^{QD} = A\beta U_{xy}(\sigma_x H_y + \sigma_y H_x).$$

The constant  $A$  was experimentally determined by Wilson and Feher<sup>12</sup> as  $A = 0.44$ . The  $T_1$  time due to  $H_{\text{one-valley}}^{QD}$  can be readily calculated and is given by<sup>17</sup>

$$\begin{aligned} \frac{1}{T_1^{\text{one-valley}}} &= \frac{2\pi^4 A^2 \hbar}{5g^2 \rho v_t^5} \left( \frac{g\mu B}{2\pi \hbar} \right)^5 [1 + 2n_B(g\mu B)] \\ &\times \sin^2 \theta (\cos^2 2\phi + \cos^2 \theta \sin^2 2\phi), \end{aligned}$$

where  $(\theta, \phi)$  define the angle of the magnetic field relative to [001].  $n_B$  is the Bose function.  $g$  can be taken as  $g = 2$  when computing spin splittings. It is evident that this equation produces infinite relaxation times if the magnetic field points along the [001] or [011] axes. Figure 4 plots the one-valley relaxation rate as a function of magnetic field direction. We particularly stress that the  $B^5$  dependence of  $1/T_1$  is the characteristic signature of this mechanism and that this rate is very small in general. The angular variation with field is also very characteristic and has the remarkable feature that the rate vanished for particular angles.

## B. Dot-specific mechanisms

Now we consider SOC that comes from the dot structure itself. The spin-orbit Hamiltonian for a 2D electron is conventionally written as

$$H_{so} = \alpha(\sigma_x k_y - \sigma_y k_x) + \beta(\sigma_x k_x - \sigma_y k_y),$$

where  $k_x, k_y$  are the in-plane wave vector components and  $\alpha$  and  $\beta$  are the strengths of the so-called Rashba and Dresselhaus spin-orbit terms, respectively. This, combined with electron-phonon coupling, can also produce spin relaxation, and the



effect (with  $\alpha = 0$ ) has been computed for GaAs QDs (Ref. 18). In Si QDs, there is SIA SOC that comes from the fact that the mirror symmetry  $z \leftrightarrow -z$  is broken. This occurs in SiGe/Si/SiGe heterostructures and in MOSFET-type QDs either by modulation doping or by a top-gate induced electric field.<sup>21</sup> In contrast, Dresselhaus SOC has traditionally been assumed to be absent in Si structures because bulk Si has inversion symmetry. It was recently shown<sup>25,26</sup> that this is not the case. The breaking of inversion symmetry by the interfaces gives a nonzero Dresselhaus-like term that can be surprisingly large.<sup>26</sup> This has yet to be verified experimentally. Often, experimental measures of spin relaxation involve terms proportional to  $\alpha^2 + \beta^2$  so the terms are hard to verify independently. Therefore, we keep both terms in  $H_{so}$  and compute the spin relaxation that comes from these asymmetry-induced effects. The results differ from those of the GaAs quantum dot analog due to the many-valley nature of silicon and the dominance of acoustic over piezophonons in silicon.

The orbital energy level splittings are much reduced in quantum dots relative to donors (see Fig. 1) because of the more shallow potential. It is thus relatively easy to make the Zeeman splitting larger than the orbital splitting. However, for quantum computing the likely situation is for the Zeeman splitting to be less than the orbital splitting to maintain a good qubit manifold. Here we consider only this case where the magnetic field splitting is small compared to the orbital splitting. We comment on this approximation further below. In Si, the Hamiltonian for the electron-phonon matrix element is, for  $v = v'$ ,

$$\begin{aligned} \langle ms | H_{ep} | ns' \rangle_{\mathbf{q}\lambda} &= i\delta_{s,s'} \langle m | [a_{\mathbf{q}\lambda}^* e^{-i\mathbf{q}\cdot\mathbf{r}} + a_{\mathbf{q}\lambda} e^{i\mathbf{q}\cdot\mathbf{r}}] | n \rangle \\ &\quad \times q [(\Xi_d \mathbf{e}_x(\mathbf{q}, \lambda) \hat{q}_x + \Xi_d \mathbf{e}_y(\mathbf{q}, \lambda) \hat{q}_y \\ &\quad + (\Xi_d + \Xi_u) \mathbf{e}_z(\mathbf{q}, \lambda) \hat{q}_z)], \end{aligned}$$

where  $|ns\rangle$  denotes a state with an electron in the  $n$ th level of the dot with spin  $s$ . Again, we consider relaxation

processes within the same valley state. A phonon with wave vector  $\vec{q}$  and polarization  $\lambda$  is absorbed or emitted depending on whether  $E_n > E_m$  or  $E_n < E_m$ .  $s = \uparrow, \downarrow$  is the spin projection on the  $z$  axis, defined to be along the external applied field  $\vec{B} = B(\sin \Theta \cos \Phi, \sin \Theta \sin \Phi, \cos \Theta)$ . Hence,  $|\uparrow\rangle = \begin{pmatrix} e^{-i\Phi/2} \cos \Theta/2 \\ e^{i\Phi/2} \sin \Theta/2 \end{pmatrix}$ , etc.

The matrix elements of  $H_{so}$  are  $\langle ms | H_{so} | ns' \rangle = im_t E_{mn} [(\alpha y_{mn} + \beta x_{mn}) \sigma_x^{ss'} - (\alpha x_{mn} + \beta y_{mn}) \sigma_y^{ss'}]$ , where  $x_{mn} = \langle m | x | n \rangle$  is the dipole matrix element for the dot states,  $\hat{\sigma}_x^{\uparrow\downarrow} = -\cos \varphi \cos \vartheta - i \sin \varphi$  and  $\hat{\sigma}_y^{\uparrow\downarrow} = -\sin \varphi \cos \vartheta + i \cos \varphi$ , and where we have used the trick  $(p_x)_{kn} = im E_{kn} x_{kn} / \hbar$ ; we use units with  $\hbar = 1$ .  $H_{so}$  causes the eigenstates to be mixtures of up- and down-spin states. For example, if the unperturbed orbital ground states  $|0\uparrow\rangle^{(0)}$  and  $|0\downarrow\rangle^{(0)}$  are perturbed by  $H_{so}$ , the new eigenstates  $|0\uparrow\rangle^{(1)}$  and  $|0\downarrow\rangle^{(1)}$  are, e.g.,

$$\begin{aligned} |0\uparrow\rangle^{(1)} &\approx |0\uparrow\rangle^{(0)} + im_t \sum_{m \neq 0} (1 + g\mu_B B / E_m) \\ &\quad \times [(\alpha y_{m0} + \beta x_{m0}) \sigma_x^{\downarrow\uparrow} - (\alpha x_{m0} + \beta y_{m0}) \sigma_y^{\downarrow\uparrow}] |m\downarrow\rangle, \end{aligned}$$

where  $m_t$  is the transverse mass and we have expanded around  $g\mu_B B$  with  $\frac{1}{E_{nk} \pm g\mu_B B} = \frac{1}{E_{nk}} (1 \mp \frac{g\mu_B B}{E_{nk}} + \dots)$ . The (1) superscript indicates first order in  $|H_{so}|/E_m$ , the spin-orbit splitting compared to the orbital excitation energies. It is important to compute the  $g\mu_B B/E_m$  correction for reasons that will soon become apparent.

Our interest is in the matrix element

$$\langle 0\uparrow | H_{ep} | 0\downarrow \rangle_{\mathbf{q}\lambda},$$

where the  $\mathbf{q}\lambda$  subscript indicates that there is a phonon in the final state. We find

$$\begin{aligned} \langle 0\uparrow | H_{ep} | 0\downarrow \rangle_{\mathbf{q}\lambda} &= i\delta_{s,s'} \langle (0) | a_{\mathbf{q}\lambda} | (1) \rangle q [(\Xi_d \hat{e}_x(\lambda) \hat{q}_x + \Xi_d \hat{e}_y(\lambda) \hat{q}_y + (\Xi_d + \Xi_u) \hat{e}_z(\lambda) \hat{q}_z)] \\ &\quad \times \left\{ \langle 0\uparrow |^{(0)} - im_t \sum_{m \neq 0} (1 + g\mu_B B / E_m) [(\alpha y_{0m} + \beta x_{0m}) \sigma_x^{\downarrow\uparrow} - (\alpha x_{0m} + \beta y_{0m}) \sigma_y^{\downarrow\uparrow}]^* \langle m\downarrow | \right\} \delta_{s,s'} e^{i\vec{q}\cdot\vec{r}} \\ &\quad \times \left\{ |0\downarrow\rangle^{(0)} + im_t \sum_{m \neq 0} (1 - g\mu_B B / E_m) [(\alpha y_{0m} + \beta x_{0m}) \sigma_x^{\uparrow\downarrow} - (\alpha x_{0m} + \beta y_{0m}) \sigma_y^{\uparrow\downarrow}] |m\uparrow\rangle \right\}, \end{aligned}$$

and we make the ED approximation  $e^{i\mathbf{q}\cdot\mathbf{r}} \approx 1 + i\mathbf{q}\cdot\mathbf{r}$ , which gives

$$\begin{aligned} \langle 0\uparrow | H_{ep} | 0\downarrow \rangle_{\vec{q}\lambda} &= -2im_t \sum_{i=x,y,z} \sum_{m \neq 0} \frac{g\mu_B B}{E_m} r_{m0}^{(i)} q [(\alpha y_{0m} + \beta x_{0m}) \sigma_x^{\uparrow\downarrow} - (\alpha x_{0m} + \beta y_{0m}) \sigma_y^{\uparrow\downarrow}] \\ &\quad \times \sqrt{\frac{1}{2M_c \omega_{\vec{q}\lambda}}} [(\Xi_d \hat{e}_x(\lambda) \hat{q}_x + \Xi_d \hat{e}_y(\lambda) \hat{q}_y + (\Xi_d + \Xi_u) \hat{e}_z(\lambda) \hat{q}_z)] q_i. \end{aligned}$$

Because  $(H_{so})_{kn}^{\downarrow\uparrow} = -(H_{so})_{kn}^{\uparrow\downarrow}$ , the overall matrix element is reduced by roughly  $g\mu_B B/E_m$ . This is the manifestation of the so-called Van Vleck cancellation.

We do the thermal average over phonon states and apply Fermi's golden rule. This yields

$$\begin{aligned} \frac{1}{T_1} &= 2\pi \sum_{\vec{q}\lambda} [1 + 2n_B(\omega_{\vec{q}\lambda})] |\langle 0\uparrow | H_{ep} | 0\downarrow \rangle_{\vec{q}\lambda}|^2 \delta(g\mu_B B - v_\lambda q) = \frac{m_t^2}{2\pi^2 \rho} (g\mu_B B)^7 \sum_{\lambda} \frac{1}{v_\lambda^7} \sum_{m,n \neq 0} S_m S_n^* \frac{1}{E_m E_n} \\ &\quad \times \int d\Omega_{\vec{q}} (\hat{q} \cdot \vec{r}_{m0}) (\hat{q} \cdot \vec{r}_{n0}) [(\Xi_d \hat{e}_x(\lambda) \hat{q}_x + \Xi_d \hat{e}_y(\lambda) \hat{q}_y + (\Xi_d + \Xi_u) \hat{e}_z(\lambda) \hat{q}_z)]^2, \end{aligned}$$

where

$$S_m = [(\alpha y_{0m} + \beta x_{0m})\sigma_x^{\uparrow\downarrow} - (\alpha x_{0m} + \beta y_{0m})\sigma_y^{\uparrow\downarrow}].$$

The integral is over the directions of  $\mathbf{q} = q(\sin\theta \cos\phi, \sin\theta \sin\phi, \cos\theta)$ . ( $\theta$  and  $\phi$  are not the same as  $\Theta$  and  $\Phi$ , which give the directions of the magnetic field.)

Following Ref. 19, we now define the dot polarization tensor,

$$\xi_{ij} = -2e^2 \sum_m \frac{(x_i)_{m0}(x_j)_{0m}}{E_m},$$

where the sum is over all the orbital states. The opposite valley states are not included in the sum since the intervalley electron-phonon coupling is assumed to be small (this could be different in nonideal interfaces). It is also reasonable to neglect  $z_{m0}$ , since the spatial extent of the wave function in the growth direction is small compared to  $x_0, y_0$  (at least by a factor of 10). The result (with  $\hbar$  restored) is

$$\begin{aligned} \frac{1}{T_1} = & \Upsilon_{xy} \frac{m_i^2}{\pi \hbar^{10} \rho_{\text{Si}}} (g\mu_B B)^7 \frac{1}{e^4} [1 + 2n_B(g\mu_B B)] \{[(\alpha^2 + \beta^2)(\xi_{xx}\xi_{xx} + \xi_{yx}\xi_{yx} + \xi_{xy}\xi_{xy} + \xi_{yy}\xi_{yy}) + 2\alpha\beta(\xi_{xx}\xi_{xy} \\ & + \xi_{yx}\xi_{yy} + \xi_{xy}\xi_{xx} + \xi_{yy}\xi_{yx})] \left(\frac{3}{4} + \frac{1}{4} \cos 2\Theta\right) + (\alpha^2 - \beta^2)(\xi_{xx}\xi_{xx} + \xi_{yx}\xi_{yx} - \xi_{xy}\xi_{xy} - \xi_{yy}\xi_{yy}) \sin^2 \Theta \cos 2\Phi \\ & + \frac{1}{2}[(\alpha^2 + \beta^2)(\xi_{xx}\xi_{xy} + \xi_{yx}\xi_{yy} + \xi_{xy}\xi_{xx} + \xi_{yy}\xi_{yx}) + 2\alpha\beta(\xi_{xx}\xi_{xx} + \xi_{yx}\xi_{yx} + \xi_{xy}\xi_{xy} + \xi_{yy}\xi_{yy})] \sin^2 \Theta \sin 2\Phi\}. \end{aligned} \quad (11)$$

Note that we include a factor of two in the phonon population multiplier,  $1 + 2n_B$ , so to satisfy the traditional definition of  $T_1$  where both relaxation and excitation are possible (although at very low temperature this term goes to one). The most striking qualitative feature of this expression is the  $B^7$  dependence,<sup>3</sup> this can be considered as the characteristic feature of dot-specific SOC and contrasts with the  $B^5$  dependence of bulk SOC, as well as GaAs quantum dots (which are dominated by piezophonon relaxation in energy regimes of interest).<sup>19</sup> In addition, there is field anisotropy. To understand this anisotropy, note that the diagonal elements  $\xi_{xx} \approx \xi_{yy}$  are likely to dominate the off-diagonal elements  $\xi_{xy}$  and  $\xi_{yx}$ . Examination of the expression then shows that the largest term in  $1/T_1$  is proportional to  $(\alpha^2 + \beta^2)(3 + \cos 2\Theta)/4$ . This does not vanish when  $\vec{B}$  is along the  $z$  axis ( $\Theta = 0$ ), again in contrast to the Roth-Hasegawa contributions. If one wishes to determine  $\alpha$  and  $\beta$  individually, then the smaller contribution proportional to  $(\alpha^2 - \beta^2) \sin^2 \Theta \cos 2\Phi$  must be measured. It could be enhanced if  $\xi_{xx}$  is very different from  $\xi_{yy}$ , which would be the case for a very elliptical dot.

The polarization tensors (matrix elements) can be calculated numerically, or in the small magnetic field limit (where the first excitation energy is much less than the Landau energy), the zero B-field parabolic matrix elements can be used as a decent approximation. We can include the magnetic field in a circular dot explicitly if  $B \parallel z$  by utilizing the Fock-Darwin states.<sup>53</sup> In this case,  $\langle 00|x|01\rangle = \langle 00|y|10\rangle = |\sqrt{2}L_B/2|$ , where  $\hbar\omega_0$  is the fundamental energy of the dot,  $L_B = 2\sqrt{\hbar/(m^*\Omega)}$ ,  $\Omega = \sqrt{\omega_0^2 + \omega_c^2/4}$ ,  $\omega_c = eB/m^*$ ,  $E_{00,01} = \hbar\omega_-$ ,  $E_{00,10} = \hbar\omega_+$ , and  $\omega_{\pm} = \sqrt{\omega_0^2 + \omega_c^2/4} \pm \omega_c/2$ . Then, taking into account dipole selection rules (only transitions  $n'_{\pm} = n_{\pm} \pm 1$  are allowed),

$$\xi_{xx} = \xi_{yy} = -e^2 \left(\frac{L_B}{2}\right)^2 \left[\frac{1}{\hbar\omega_-} + \frac{1}{\hbar\omega_+}\right] \quad \text{and} \quad \xi_{xy} = \xi_{yx} = 0.$$

In the  $B = 0$  limit, with  $L = L_B(B = 0)$ , the equation above reduces to  $\xi_{xx} = \frac{e^2}{m^*\omega_x^2}$  and  $\xi_{yy} = \frac{e^2}{m^*\omega_y^2}$  for an elliptical dot.

To estimate the overall quantitative magnitude we assume a circular dot with a parabolic potential [note also that for a circular dot  $\xi_{xx}(B_z) = \xi_{yy}(B_z) = \xi_{xx}(0)$ ]. Then with  $\xi_{xx} = \xi_{yy} = \xi$  and  $\xi_{xy} \approx \xi_{yx} = 0$  and

$$\frac{1}{T_1^{QD}} = \frac{1}{105} \Xi_u^2 \frac{(\alpha^2 + \beta^2) (g\mu_B B)^7}{\pi \hbar^6 \rho_{\text{Si}} v_i^7} \frac{1}{E_{10}^4} (3 + \cos 2\Theta) [1 + 2n_B(g\mu_B B)], \quad (12)$$

where we have used

$$\left|\frac{\xi}{e^2}\right|^2 = \frac{\hbar^4}{m_i^2 E_{10}^4} = \frac{m_i^2 L^8}{2^4 \hbar^4} \quad (13)$$

(for reference we find  $E_{10} = \frac{2\hbar^2}{m_i L^2}$ ). The contribution of longitudinal ( $\ell$ ) phonons is suppressed by roughly a fifth in  $\Upsilon_{xy}$  and is neglected. For reference, the spin-relaxation rate can also be written in terms of the dipole matrix elements between  $1s$  and  $2p$ ,  $M^{(10)}$ , as (assuming mixing to one excited state)

$$\frac{1}{T_1^{QD}} = \frac{4}{105} \Xi_u^2 \frac{(\alpha^2 + \beta^2) (g\mu_B B)^7 |M^{10}|^4}{\pi \hbar^6 \rho_{\text{Si}} v_i^7} \frac{1}{E_{10}^2} (3 + \cos 2\Theta) [1 + 2n_B(g\mu_B B)]. \quad (14)$$

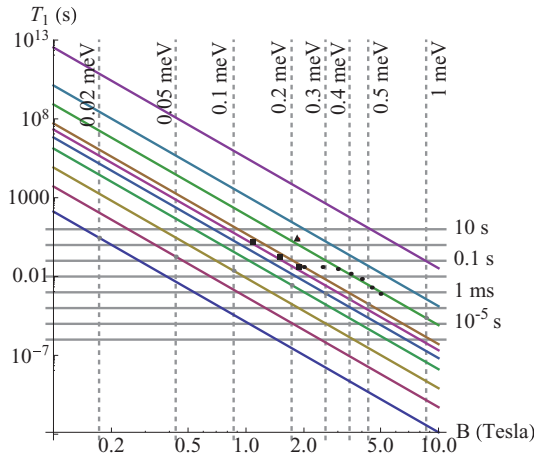


FIG. 5. (Color online) Spin-relaxation time,  $T_1$ , for an ideal, circular quantum dot as a function of magnetic field as calculated from Eq. (12) for SOC constant value (which can vary greatly from device to device) of  $\sqrt{\alpha^2 + \beta^2} = 4 \mu\text{eV nm}$  (taken from a SiGe QW experiment;<sup>49</sup> see text) and  $B \parallel [110]$  ( $T_1$  for  $B \parallel \hat{z}$  is a factor of 2 longer). Diagonal lines for spin-relaxation times from bottom to top are for different orbital energy splittings (dot size gets smaller going up) of  $\Delta = 0.02, 0.05, 0.1, 0.2, 0.3, 0.4, 0.5, 1, 2,$  and  $8 \text{ meV}$ , respectively. Theory is only appropriately compared to experiment below degeneracy points (given by intersection of vertical and diagonal lines). Any possible spin “hot spots” would occur at degeneracy between Zeeman and first excited-state splitting (which is approximately 0.3–0.4 meV in these size dots). Points represent presently published experimental data for a SiGe quantum dot from HRL (squares),<sup>50</sup> a SiO<sub>2</sub> quantum dot (circles) from UCLA,<sup>51</sup> and a SiGe quantum dot (triangle) from Wisconsin.<sup>52</sup> Lifetimes are calculated in the approximation that  $B \ll \Delta$ , which means that, for example, the lowest diagonal line will begin to deviate from the straight line shown when  $B < 0.2 \text{ T}$ .

The magnitudes of  $\alpha$  and  $\beta$  are material-system- and device-specific. Wilamowski *et al.*<sup>49</sup> have measured  $\alpha_W = 0.55/\sqrt{2} \times 10^{-12} \text{ eV cm} = 4 \mu\text{eV nm}$  via 2DEG spin relaxation in Si/SiGe quantum wells. On the other hand, for a SiGe/Si/SiGe well and a field of  $10^7 \text{ V/m}$  (roughly a factor of 2 larger  $E$  field than typical SiGe QW QDs but about right for SiO<sub>2</sub> dots), Prada *et al.*<sup>26</sup> theoretically find that  $\beta > \alpha$  and  $\beta = 5.77 \mu\text{eV nm} = 9.2 \times 10^{-34} \text{ J m}$ ; note that they mention that the  $\beta$  term could decrease in (typical) heterostructure quantum wells with miscut and that it will vary from device to device. Calculations of the spin relaxation in 2DEGs<sup>20,21</sup> give  $1/T_1^{2\text{DEG}} \propto (\alpha^2 + \beta^2)$ , assuming minimal cyclotron effects or  $B \parallel (x, y)$ ; so the two results are consistent if we attribute the Wilamowski result as due to  $\beta$ . Nestoklon *et al.*,<sup>24</sup> also theoretically, find a value for  $\beta$  roughly 6 times smaller than Wilamowski *et al.*<sup>49</sup> ( $\beta_N = 15.6, \alpha_N = 5.2 \mu\text{eV nm}$ ). Note that the measured line width in Ref. 49 does not depend on the in-plane orientation of the magnetic field, implying (at least for that device) that one SOC term dominates over the other.<sup>20,21</sup>

Figure 5 plots Eq. (12) for  $B \parallel [110]$  as a function of orbital energy splitting using the result of Wilamowski *et al.*,  $\alpha_W = \sqrt{\alpha^2 + \beta^2}$ , and substituting values from Table I. Also shown are some recent experimental results<sup>50–52</sup> which follow the  $B^7$  trend but generally show longer lifetimes. We defer

our comparison to experiment to the Discussion section below. Note that our results are for the ED approximation, shown in the previous section to be a good approximation (as a bound on  $T_1$  useful for quantum computing) below  $\sim 1 \text{ meV}$ . Calculations that attempt to calculate the spin relaxation beyond the dipole approximation<sup>54,55</sup> have shown the possibility of fast spin relaxation (“hot spot”) when the orbital and Zeeman energies are degenerate: a result of orbital-spin level mixing. This mixing is contingent on the nature of the SOC mixing: Dresselhaus (no mixing) or Rashba (mixing). Unfortunately, we do not know the nature of the SOC in these devices and indeed it may depend on microscopic details and may vary from device to device (even on the same chip). An additional complication arises when the first excited state is a valley state or valleylike, a situation we discuss later in the text. So a hot spot is not assured. Therefore, we mark these crossovers in energy in Fig. 5 as a possible position of interesting physics (fast relaxation) which may tell us more about the nature of these states. Our results are relevant for the quantum computing situation where  $g\mu B < \Delta$  and likely a good approximation beyond the crossing point (with the cyclotron modified wave function incorporated).

### C. Electrical and magnetic noise

Another possible mechanism that could limit  $T_1$  in Si/SiGe quantum dots is the electric and magnetic noise coming from trapped charges and other two-level systems, noise in the circuitry, thermal and quantum current fluctuations in nearby conductors, etc. In this section we point out how the presence of this sort of noise could be indicated by lifetime measurements and how it can be distinguished from the other sources of noise we have been considering in this paper.

Electrical noise from a random field  $\vec{E}(t)$  can produce spin relaxation if there is SOC present. Relaxation can occur by two distinct mechanisms: (1) spin-orbit-mediated virtual excitation to higher orbital states with spin flip and (2) modulation of the Rashba field. These correspond roughly to the Elliot-Yafet and D’yakonov-Per’el mechanisms in bulk.

For the first mechanism we have a Hamiltonian,

$$H = -\frac{1}{2}g\mu_B\mathbf{B} \cdot \boldsymbol{\sigma} - e\mathbf{E}(t) \cdot \vec{r} + \alpha \left( \sigma_x \frac{\partial}{\partial y} - \sigma_y \frac{\partial}{\partial x} \right) + \beta \left( \sigma_x \frac{\partial}{\partial x} - \sigma_y \frac{\partial}{\partial y} \right).$$

This produces relaxation that is physically analogous to the spin-phonon mechanism, and the derivation is parallel, so we omit it. We obtain

$$\frac{1}{T_1} = \eta \frac{(em_t g\mu_B B)^2}{\hbar^2} S_{E_x}(g\mu_B B/\hbar) \left( \frac{4^2 \hbar^4}{m_t^2 E_{10}^4} \right) (\alpha + \beta)^2 \times (1 + \cos^2 \Theta)(1 - \sin 2\Phi), \quad (15)$$

where  $S_{E_x}(g\mu_B B/\hbar)$  is the spectral density of the  $E_x$  autocorrelation function evaluated at the qubit operating frequency,  $L$  is a measure of the diameter of the dot, and we assume the fluctuating field points along  $E_x$  for this result.  $\eta$  is a numerical factor of order one that depends on the shape of the dot. We write the applied field  $\vec{B}$  as  $\vec{B} = B(\sin \Theta \cos \Phi, \sin \Theta \sin \Phi, \cos \Theta)$ .  $\Theta = 0$  is the  $z$  axis

of the laboratory frame. Note that, as before, the relaxation rate decreases as the excited-state splitting increases since the spin mixing which allows the electric field to relax the qubit is via the excited orbital state. Also note that it is clear from from Eq. (15) that the relaxation rate is proportional to  $S_{E_x}(g\mu_B B/\hbar)B^2L^8$ .

The second mechanism is physically distinct in that it does not involve orbitally excited states; instead, the noise is converted to random time-dependent effective magnetic field on the spin. It is sufficient to consider a Rashba Hamiltonian,

$$H = -\frac{1}{2}g\mu_B\mathbf{B}\cdot\boldsymbol{\sigma} - e\alpha_1^0 E_z(t)\left(\sigma_x\frac{\partial}{\partial y} - \sigma_y\frac{\partial}{\partial x}\right),$$

which leads to

$$\frac{1}{T_1} = \eta' \frac{e^2}{\hbar^2 L^2} (\alpha_0^1)^2 S_{E_z}(g\mu_B B/\hbar),$$

where again  $\eta'$  is a geometry-dependent constant of order unity. Here the rate increases with smaller dot sizes ( $L^2 = 2\hbar^2/m_t E_{10}$ ). Reasonable values for the parameters are  $\alpha_0^1 = 10^{-5} \text{ nm}^2$  (Ref. 26) and  $L = 50 \text{ nm}$ ; evaluating this formula leads to

$$\frac{1}{T_1} \sim 0.1 \times S_{E_z}(g\mu_B B/\hbar),$$

if  $S_{E_z}(g\mu_B B)$  is measured in  $\text{V}^2 \text{ s/m}^2$  and  $1/T_1$  is measured in  $\text{s}^{-1}$ . Zimmerman *et al.* determined the strength of electrical noise in a Si SET structure by measuring fluctuations in the peak separations of Coulomb blockade oscillations, but so far this type of measurement has been performed only at frequencies much less than 1 GHz, which makes it difficult to estimate the noise magnitude at typical qubit operating frequencies in real structures. However, the only  $B$  dependence in  $T_1$  comes from  $S_{E_z}(g\mu_B B/\hbar)$ , which is likely to vary extremely slowly with  $B$  for any mechanism that one can think of. This means that defect-dominated electrical noise can be easily distinguished from other relaxation mechanisms by the fact that it is  $B$  independent.

Magnetic noise from quantum and thermal current fluctuations in metallic portions of the circuit will produce a fluctuating magnetic field at the qubit that can relax the spin. No SOC is required for this mechanism to operate. This effect has recently been calculated by Langsoen *et al.*<sup>28</sup> These authors found values of  $T_1$  on the order of seconds for typical quantum dot architectures. The field and temperature dependence is given by  $1/T_1 \sim B \coth(\mu_B B/2k_B T)$ , which reflects the photon density of states and the Bose function. The field and temperature dependencies are again distinctive. The field dependences in particular are summarized in Fig. 6.

#### D. Spin relaxation due to nuclei

Hyperfine coupling of the electron spin to nuclei has attracted a great deal of attention in connection with qubit experiments in GaAs, since it is the main source of decoherence.<sup>56–59</sup> However, this arises entirely from dephasing ( $T_2$  processes). The nuclear system is incapable of absorbing or emitting the energy required to relax the excited state of an electron in a quantum dot. Nuclear magnetic moments  $\mu_n$  are about  $10^{-3}$  times the size of the electron moment  $\mu_B$  and this translates into a similar energy mismatch:  $\mu_n B \ll \mu_B B$  in a magnetic field  $B$ , so mutual spin-flip transitions are forbidden by energy conservation. The only remaining possibility is the modulation of the hyperfine coupling of electrons and nuclei by phonons. The relaxation rate  $1/T_1$  has been computed in Refs. 7, 19, and 27. It is

$$\frac{1}{T_1} = \frac{(g\mu_B B)^3 \gamma^2 \omega_N^2}{\hbar^2 v_i^5 n_{\text{Si}}},$$

where  $n_{\text{Si}}$  is the number density of silicon and  $\omega_N^2 = A^2/\hbar^2 n_{\text{imp}} v_0$  is the square of the electron precession frequency in the effective hyperfine field of the  $^{29}\text{Si}$  nuclei.  $A$  is the hyperfine interaction constant,  $n_{\text{imp}}$  is the density of  $^{29}\text{Si}$  nuclei,  $v_0$  is the rms volume of the wave function of the electron, and  $\gamma = (1/m^*)(dm^*/dD)$  is the fractional change in the effective mass of the electron in the presence of a dilatation  $D$ . For a  $v_0$

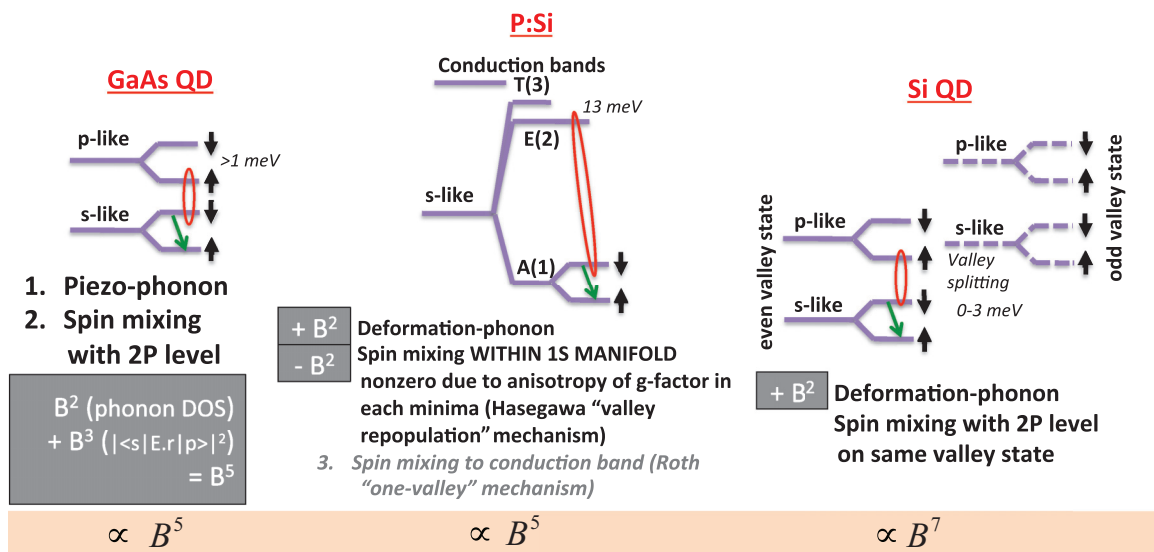


FIG. 6. (Color online) Schematic summary of the mechanisms behind the different field dependencies of the spin relaxation rate for GaAs dots, for which  $1/T_1 \sim B^5$ , for Si donor states dots, for which  $1/T_1 \sim B^5$ , and for ideal Si dots, for which  $1/T_1 \sim B^7$ .

of order  $(30 \text{ nm})^3$  and  $B$  of 1 T, we obtain  $T_1$  of order  $10^5$  s for natural Si with a  $^{29}\text{Si}$  concentration of 4.7%. The  $B^3$  field dependence is interesting since it contrasts with the higher powers of  $B$  for other mechanisms. Unfortunately, the magnitude is apparently too small for it to be observed in quantum dot electrons at the fields and temperatures under consideration here. It might be hoped that the effect could be observed in donor impurity states where the lack of strain would suppress spin-phonon coupling. However, even here  $T_1 = 0.25 \times 10^4$  s at  $B = 0.32$  T and  $T = 1.25$  K (Refs. 6 and 12) in lightly doped Si:P. That has been shown to be due to the spin-phonon coupling mechanism. Hence, it appears that hyperfine coupling is not important for spin relaxation in dot states. This conclusion would be even stronger in isotopically purified Si.

### E. Two-phonon processes

At higher temperatures there is an activated two-phonon contribution from SOC mixing in silicon quantum dots. The Orbach process we consider here involves a phonon excitation of the excited spin to the higher orbital state (with a spin flip) followed by fast phonon relaxation to the ground state (typically a virtual process). In the Si:P system, these Orbach processes dominate for  $T > 2$  K (Ref. 60). We can use the methods proposed by Castner<sup>14</sup> to roughly estimate the SOC+Orbach spin-relaxation path. We arrive at

$$\frac{1}{T_1^{\text{Orbach}}} \approx M_{SO}^2 \Gamma_{1 \rightarrow g} n(E_{10}),$$

where we estimate for a circular dot that  $M_{SO} \approx \langle 1\uparrow|x|g\downarrow \rangle / \langle 1|x|g \rangle \approx 2(\alpha + \beta)\sqrt{m^*/E_{10}}$  as the spin-mixing of the two states and  $\Gamma$  is the orbital relaxation time of the first excited state. For a circular dot with a parabolic potential,

$$\frac{1}{T_1^{\text{Orbach}}} \approx \gamma_{xy} \frac{8(\alpha^2 + \beta^2)|E_{10}|^3}{\hbar^4 \pi \rho_{\text{Si}}} \exp[-|E_{10}|/kT]. \quad (16)$$

Thus, the temperature dependence of  $T_1$  at higher temperatures can give an accurate measure of  $E_{10}$ , a technique already used to find energy splittings of donor states. This can provide

a check on transport spectroscopy determinations of this quantity.

## VIII. VALLEY RELAXATION

Electrons in lateral silicon quantum dots typically reside in the two degenerate CB minima along the  $z$  direction (see Fig. 7). This doubles the number of levels in the dot relative to the  $\Gamma$ -point-centered, direct band gap III-V quantum dots as was described in Sec. III. Here we wish to consider the relaxation times of these excited valley states as we have done for low-lying orbital and spin states above. Castner was the first to calculate the relaxation across different valley states from the  $2p$  to  $1s$  levels in donors.<sup>13</sup> This has been repeated in Ref. 4 for Li donors and for P and Li in strained silicon in Ref. 33. A similar calculation can be done for lateral quantum dots where the interface in  $z$  is assumed to be perfectly flat and smooth, and thus the valleys can be considered good quantum numbers in the usual Kohn-Luttinger approximation (and the problem is separable in the three dimensions). We first consider this ideal (or “1D”) case (which may be relevant in some experimental situations) and then comment on the more usual case of significant valley-orbital wave function mixing due to imperfect interfaces.

### A. Ideal (1D) interfaces

We are concerned with relaxation across the same orbital and spin states but between valley states ( $v = +/−$ ) in a silicon quantum dot, particularly the relaxation of the lowest excited valley state with no change in spin or orbital number (type 3 in Fig. 2). Our approach to valley relaxation follows the same procedure as exact orbital relaxation (Sec. VI and the Appendix), where in this case we replace the matrix element with the intervalley matrix element:

$$M_{+-} = \langle ns+ | H_{ep} | ns- \rangle.$$

Assuming no valley-orbit mixing with higher states [separable wave functions in  $(x, y)$  and  $z$ ], the wave function for an

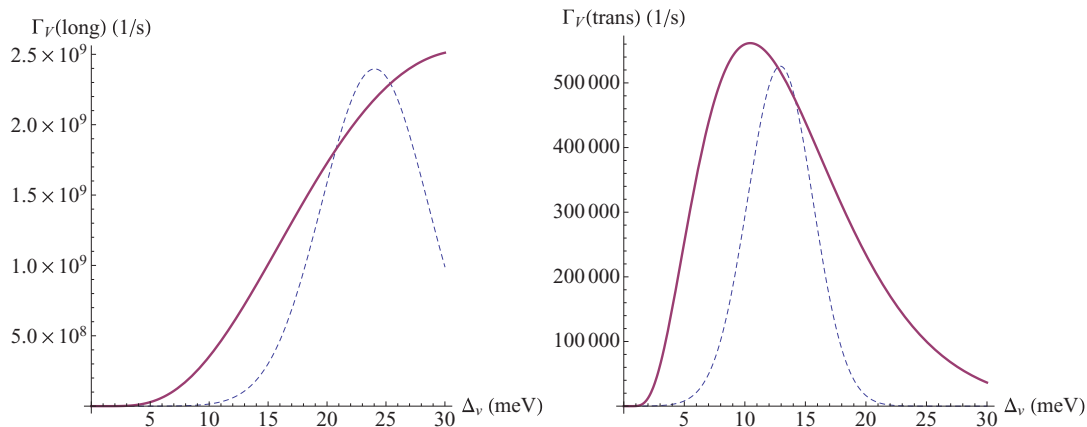


FIG. 7. (Color online) Longitudinal (left) and transverse (right) phonon valley relaxation rates for ideal interfaces versus valley splitting,  $\Delta_v$ . The dashed lines are with the height of the wave function,  $z_0$ , held constant (note the peaks at 23 and 11 meV, respectively) and the solid lines are the relaxation rates with the changing extent of the wave function in  $z$  (due to the electric field) included by using the theory of Ref. 34. Note that the tighter the confinement in  $z$ , the faster the relaxation (due to broadening of the wave function in momentum space.) These numbers are for  $|C_G|^2 = 1$  and should be renormalized down by  $u_{k1}^2$  (see the Appendix).

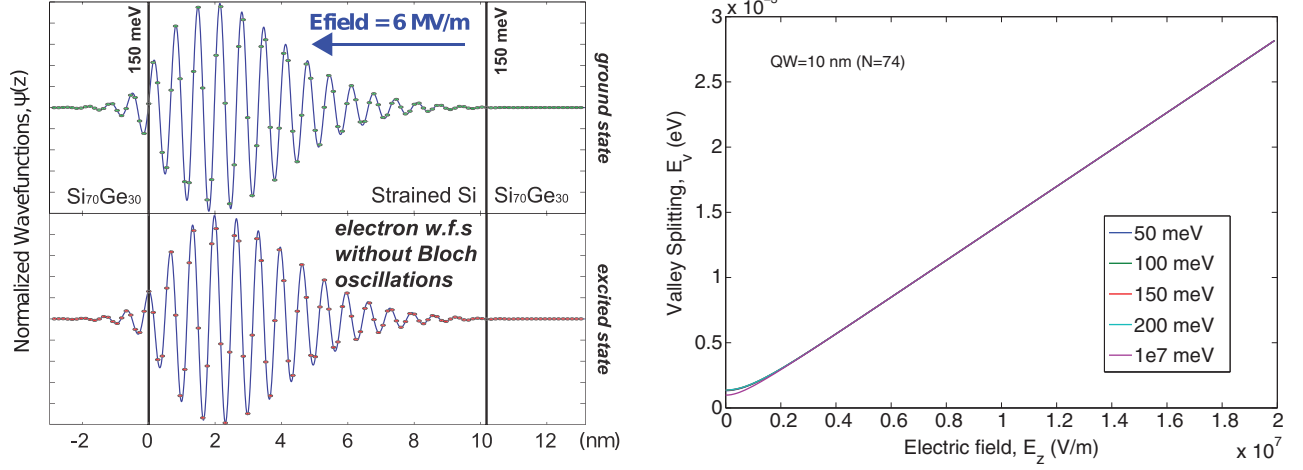


FIG. 8. (Color online) (left) Results from 1D tight-binding model for wave functions for ground and excited valley states and valley splitting for a 10-nm quantum well (corresponding to  $N = 74$  monolayers). The  $z$  component of the electron dot wave function is the output of a two-band tight-binding calculation<sup>39,61</sup> (points), which has been interpolated (line) for a typical SiGe heterostructure with a quantum well of 10 nm. (Right) Valley splitting ( $E_v$ ) as a function of growth-direction electric field for interface barriers from 50 to  $1 \times 10^7$  meV (corresponding to, roughly, 5%, 10%, 15%, 20% Ge concentration SiGe barriers and an  $\text{SiO}_2$  barrier, respectively). Valley splitting in realistic silicon quantum dots will likely be reduced versus the 1D results presented here due to interface roughness/steps, etc.<sup>34</sup>

electron in a lateral silicon quantum dot reads

$$\begin{aligned} \psi_m^{(v)}(\mathbf{r}) &= F_{x,y}(x,y)F_z(z) \left[ \alpha_z^{(v)} u_z(\mathbf{r}) e^{ik_m z} + \alpha_{-z}^{(v)} u_{-z}(\mathbf{r}) e^{-ik_m z} \right] \\ &= F_{x,y}(x,y)F_z(z) \left\{ \alpha_z^{(v)} \sum_{G_z} C_{G_z} \exp[i(G_z + k_m)z] \right. \\ &\quad \left. + \alpha_{-z}^{(v)} \sum_{K_{-z}} C_{K_{-z}} \exp[i(K_{-z} - k_m)z] \right\}, \end{aligned}$$

where  $k_m$  is the location of the minima along the  $z$  axis,  $\alpha^{(\pm)}(z, -z) = 1/\sqrt{2}\{1, \pm 1\}$  (though these may be complex in the general case), and we have expanded the Bloch function in reciprocal lattice vectors,  $\mathbf{G}$  or  $\mathbf{K}$ ,  $u(\mathbf{r}) = \sum_{\mathbf{G}} C_{\mathbf{G}} \exp[i\mathbf{G} \cdot \mathbf{r}]$ . The first five terms of the Bloch expansion contribute 90% of the wave function amplitude (values from a recent study are listed in Table 1 of Ref. 62:  $\mathbf{G}(0,0,0)$ ,  $\mathbf{G}(1, -1, -1)$ ,  $\mathbf{G}(-1, 1, -1)$ ,  $\mathbf{G}(1, 1, -1)$ ,  $\mathbf{G}(-1, -1, -1)$  in units of  $2\pi/a(x,y,z)$ , where  $|C_{+z}(\mathbf{G}_{000})|^2 \approx 0.1175$  and  $|C_{+z}(\mathbf{G})|^2 \approx 0.196$  for the other vectors). Here the envelope functions of the two states are the same, the spin states are the same, but the Kohn-Luttinger oscillations are out of phase (see Fig. 8). We assume that the wave function consists of Gaussians in all three dimensions. Following our exact orbital relaxation calculation, the valley relaxation rate of a parabolic, circular quantum dot in a [001]-strained silicon quantum well is

$$\begin{aligned} \Gamma_v &= |C_{+z}|^2 \frac{\exp(-z_0[E_v]q_u^2/4)}{4\pi\rho_{\text{Si}}\hbar} \left[ \frac{E_v^3}{\hbar^3 v_l^5} \exp\left(\frac{-x_0^2}{4} \frac{E_v^2}{\hbar^2 v_t^2}\right) \right. \\ &\quad \times (\Xi_d^2 P_l^0 + 2\Xi_d \Xi_u P_l^2 + \Xi_u^2 P_l^4) \\ &\quad \left. + \frac{E_v^3}{\hbar^3 v_t^5} \exp\left(\frac{-x_0^2}{4} \frac{E_v^2}{\hbar^2 v_t^2}\right) \Xi_u^2 (P_t^2 - P_t^4) \right], \quad (17) \end{aligned}$$

where

$$P_s^n = \int_{-1}^1 x^n \exp[A_s x^2] \sinh^2[B_s x] dx$$

and

$$A_s = \frac{1}{4} q_{\Delta s}^2 [x_0^2 - z_0^2], \quad B_s = \frac{1}{8} z_0^2 2q_{\Delta s} q_u,$$

where  $E_v$  is the valley splitting,  $z_0[E_v]$  is the extent of the wave function (assumed Gaussian) in  $\hat{z}$  as a function of the valley splitting, and  $q_u$  is the phonon wavelength of the emitted Umklapp phonon,  $q_u = 0.3k_{\text{max}}$ . The details of this calculation are given in the Appendix .

Let us compare Eq. (17) to pure orbital relaxation, Eq. (10). At first glance, the valley relaxation rate has a  $E_v^3$  dependence, as opposed to a  $E_{10}^4$  in the orbital case (assuming parabolic dot potentials for both and matrix elements given due to Gaussian wave functions). To understand this, remember that for valley relaxation this transition occurs within the lowest manifold (both initial and final states have the same  $s$ -like envelope function) such that the matrix elements  $M \sim 1$ . In the orbital case, we must calculate matrix elements from  $2p$ -like to  $1s$ -like states, such that  $M \propto x_0^2 \propto E_{10}$ . The valley relaxation expression also includes prominently an  $\exp(-z_0^2 q_u^2/4)$  prefactor absent in the exact orbital case [Eq. (10)]. This prefactor, together with the other exponential, gives phonon relaxation rate that will be peaked at the Umklapp phonon energy (assuming  $z_0$  is constant with  $E_v$ , which it is not for the dot case); see Eqs. (A7) and (A10) in the Appendix to see where this peak comes from more clearly. Equation (17) also shows the importance of the  $z_0$  extent of the wave function; decreasing  $z_0$  increases the relaxation rate (see Fig. 9). These effects are related in that Umklapp phonons at  $q_u = E_v/\hbar v_{l,t}$  which connect valleys in neighboring Brillouin zones are the most efficient relaxation channel (see the Appendix for more details). Figure 7 explicitly shows the valley relaxation rate in the two cases of fixed  $z_0$  wave-function height and

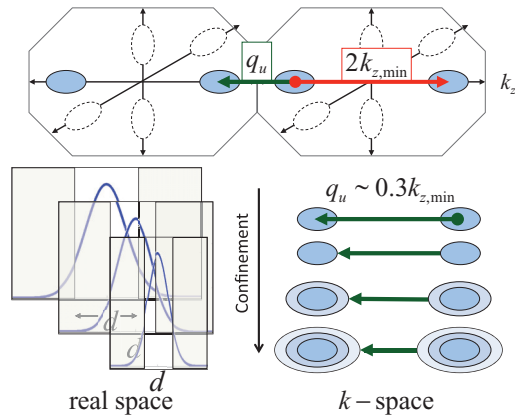


FIG. 9. (Color online) Illustration of Umklapp phonon process which enables valley relaxation in ideal, silicon quantum dots (see text and the Appendix). As the extent of the wave function is squeezed in real space, the connecting wave vector in momentum space is reduced, increasing the probability of relaxation.

wave-function height that changes accurately with electric field and valley splitting. It turns out that the Bloch coefficients to the nearest valley at  $0.3k_{\max}$  are most efficient and phonons are then emitted in the  $z$  direction. As  $z_0$  gets compressed, not only does the valley splitting increase due to interface scattering [approaching the “critical” Umklapp phonon energies at 13.4 meV (longitudinal) and 23.2 meV (transverse)], but the wave function gets broadened in momentum space, allowing lower energy phonons to connect the two opposite valleys (see Fig. 9). So Umklapp valley relaxation is possible even at valley splittings smaller than  $q_u$ . This effect causes the relaxation rate to continually increase as the valley splitting approaches  $q_u$ , while the other “typical” exponentials kick in at higher splittings to cause a bottleneck effect as in the orbital case. The linewidth should be weakly dependent on the size of the dot in the lateral dimensions (as is the valley splitting) and much more so dependent on changes in  $z$  extent of the wave function.

The valley splitting varies roughly linearly with  $E$  field in a perfect quantum well where the electron only sees one side of the quantum well. Figure 7 shows the valley relaxation for an ideal interface as a function of valley splitting with a  $z_0$  that changes correctly with  $\Delta_v$ . We account for the change of wave function size in  $\hat{z}$  as a function of valley splitting. We take the ideal theoretical maximum valley splitting as (given in J),

$$E_v = \frac{2v_v e E}{\Delta E_c} \approx 2.3 \times 10^{-29} E,$$

where  $E$  (V/m) is the electric field in the  $z$  direction,  $\Delta E_c$  is the CB offset, and  $v_v = 7.2 \times 10^{-11} \Delta E_c$  (in eV m with  $\Delta E_c$  in eV).<sup>34</sup> This compares well to the results of a tight-binding calculation for the valley splitting in different quantum wells; see Fig. 8. Thus, the valley splitting  $\Delta_v$  depends on the  $E$  field, which also determines the extent of the wave function in  $z$ .  $z_0$  now is a function of the  $E$  field in  $z$  (which varies by device and can often be changed somewhat in a single device). For this we define the wave function in  $z$  as (assuming a triangular

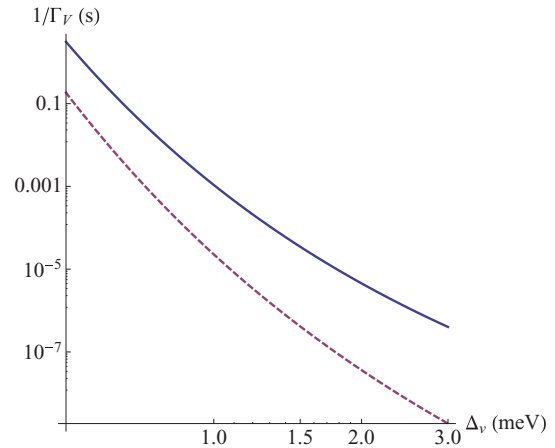


FIG. 10. (Color online) Total valley relaxation time (due to both transverse and longitudinal phonons) for an ideal interface, quantum dot excited valley state in silicon versus valley splitting,  $\Delta_v$ . The exact results including all multipole contributions are given by the blue solid line while ED approximation (see text) results are given by the purple dashed line. Typical valley splittings in silicon quantum dots are less than 1 meV.

potential)

$$\Psi_z = 1.4261 \sqrt{\kappa} \text{Ai}(\kappa z - 2.3381),$$

where  $\kappa = 1/z_0 = \sqrt[3]{2m^*eE/\hbar^2}$  (in meters). Now we replace  $E$  with  $E(E_v) = E_v/(2e \times 7.2 \times 10^{-11})$  (in V/m). Ai is the Airy function. So the extent of the wave function in  $z_0[E_v]$  changes with the valley splitting as

$$z_0[E_v] = \left[ \frac{\hbar^2 (7.2 \times 10^{-11})}{m^* E_v} \right]^{1/3}.$$

For completeness, we may also look for an expression for the valley relaxation in the ED approximation. A reasonable approximation is to set  $q_{\Delta_s}^2 = 0$  in Eq. (17), which, to leading order for a parabolic potential in all three dimensions, gives

$$\Gamma_v^{ED} \approx |C_k|^2 \exp\left(-\frac{1}{4} q_u^2 z_0[E_v]^2\right) \frac{\Xi_u^2 E_v^3}{30\pi v_l^5 \rho_{Si} \hbar^4}. \quad (18)$$

The exact and approximate valley relaxation times are compared in Fig. 10.

### B. Comments on imperfect interfaces (tilt, roughness, and alloy composition)

Our expression, Eq. (17), for valley relaxation is for perfectly smooth interfaces. As we discussed above, imperfect interfaces will cause mixing between the orbital and valley states. In realistic devices, miscut, alloy variability, surface roughness, etc., will be present. This distorts or mixes the orbital and valley states such that valley is no longer a good quantum number<sup>34</sup> (e.g., the envelope functions within the  $s$ -manifold states can now be different and/or non- $s$ -like). In this case, one must realize that the wave functions of orbital states will be different from the Gaussian wave functions assumed for  $s$ -like and  $p$ -like dot states used in the orbital relaxation section. In reality they will be not be separable, and there will be sample dependence. However, all these

energy relaxation calculations are proportional to  $M^2$ , where  $M$  is the dipole matrix element. In contrast, the energy gap dependence is much higher:  $E_{10}^5$  ( $E_{10}^4$  for parabolic dots) and the field dependence is  $B^7$ . The energy splitting is much easier to determine than  $M$  and is much more important, which means that our predictions are still useful. A likely exception is our ideal calculation for possible long-lived valley states. In the nonideal case, there is likely to be valley-orbit mixing, providing an avenue for relaxation via  $G = 0$  phonons as in the orbital relaxation case. While a full theory of this mixing is possible (utilizing appropriate wave functions, e.g., following Refs. 34 and 36), the matrix elements depend on the exact (microscopic) specification of the interface for the dot being measured (which is difficult to ascertain) and are not considered here. Because the orbital relaxation is fast, the long-lived predictions for valley excited states will be wrong in this case. Although the degree of this mixing/distortion depends on the specific device in question, we can crudely write that

$$\Gamma_v^{\text{imperfect}} = f_{\text{mix}}^2 \Gamma_{10}[E_v] + (1 - f_{\text{mix}}^2) \Gamma_v^{\text{ideal}},$$

where  $f_{\text{mix}}$  is the notional fraction of orbital wave function mixed in with the valley wave function and  $\Gamma_{10}(E_v)$  is the orbital relaxation rate across the measured valley splitting of the measured state. In some cases  $f_{\text{mix}}$  could be calculated<sup>34</sup> but generally it will depend on microscopic details of the silicon quantum dot.

## IX. COMPARISON WITH EXPERIMENTS AND CONCLUSIONS

Some spin-relaxation experiments have been performed on electrons in silicon dot devices. The various results are plotted in Fig. 5. Our theory for spin relaxation in the ED approximation should be valid only well before any degeneracy between Zeeman and orbital splitting is reached, the regime of a silicon spin qubit. In Ref. 50 (the squares in Fig. 5),  $T_1$  was measured in a lateral, depletion mode Si/SiGe quantum dot for three different magnetic fields between 1 and 2 T. Comparing to Eq. (12), the data appear to follow a  $B^{-7}$  rate but with relatively few points it is difficult to make firm conclusions. These data points fall on the 0.4 meV orbital splitting line (obtained using the value of SOC from Ref. 49), which is roughly consistent with the lithographic size of the dot but differs from the  $\Delta = 2$  meV value used for the theory model in that paper (though it is unclear if the experimental orbital splitting was measured).<sup>50</sup>

$T_1$  has also been measured in a metal-oxide-semiconductor system with the dot near the Si/SiO<sub>2</sub> interface<sup>51</sup> (the squares in Fig. 5). These authors report measuring an orbital splitting in this device of roughly 0.4 meV. There are five data points that fit a  $T_1 \sim B^{-7}$  law reasonably well; however, this behavior is observed only for  $B > 3$  T. Here theory predicts a roughly order-of-magnitude shorter spin-relaxation time for a dot with  $E_{10} = 0.4$  meV (the data  $> 3$  T behave as if the orbital splitting is 1 meV). For  $B < 3$  T,  $T_1$  is roughly independent of  $B$ , with  $T_1 = 40$  ms (possibly limited by charge noise or some other mechanism).

Finally, a recent measurement of  $T_1$  in a laterally gated Si/SiGe dot in a doped device yielded  $T_1 = 2.3$  s at a field of

$B = 1.85T$ . None of the data show evidence of hot spot (fast spin-relaxation cusp) behavior.

On the whole, these experiments give good evidence that the SOC-mediated spin-phonon interaction is the dominant channel at high fields: Both the  $B$  dependence and, importantly, the overall magnitude are consistent with theory. The value of the Rashba coefficient that is used in Fig. 5 may not be appropriate for a MOS structure (although inversion-layer spin-relaxation measurements show relaxation times<sup>63</sup> within an order of magnitude of those found in SiGe QWs) and can vary from device to device based on material, interface roughness, electric field at the interface, etc.<sup>24,26</sup> A much smaller SOC constant might explain the order-of-magnitude difference between theory and experiment for the various systems. It would be very useful in the future to attempt to characterize the SOC strength in these wafers by other means, for example via 2DEG spin relaxation,<sup>20</sup> although the SOC may vary at a microscopic level. It is also very important to check the dependence of  $T_1$  on field direction. This has not yet been done experimentally. Looking beyond the ED approximation, there may be a strong and sudden increase in the relaxation rate for spin relaxation when the spin splitting matches the orbital splitting; no such effect is expected if the first excited state is a (pure) valley state. A complication to this picture may be a lack of mixing with the orbital state if the SOC is only Dresselhaus-like<sup>54</sup> (even in the ideal case). Last, our assumption of Fock-Darwin wave functions may not be correct (do to dot asymmetry, interface roughness, etc.), leading to matrix elements between dot states that influence the relaxation rate up or down.

While these results are encouraging, they do not constitute a complete vindication of theory. Hence, we discuss how to combine the results of different measurements to fix some universal quantities. Specializing Eq. (6) to the first excited state, neglecting anisotropy and the dipole moment in the  $z$  direction, noting that  $v_t^{-7} \gg v_\ell^{-7}$ , using Eq. (7), and taking  $k_B T \ll E_{10}$ , we find an orbital relaxation rate from the first excited state to the ground state:

$$\Gamma_{10} = \frac{4|E_{10}|^5 \Xi_u^2}{105 \hbar^6 \pi \rho_{\text{Si}} v_t^7} |M_x^{(12)}|^2. \quad (19)$$

With similar assumptions for the spin relaxation and specializing to an in-plane field, we have from Eq. (12)

$$\frac{1}{T_1} = \frac{1}{21} \Xi_u^2 \frac{m_t^2}{\pi \hbar^{10} \rho_{\text{Si}} v_t^7} (g \mu_B B)^7 \frac{\xi^2}{e^4} \beta^2, \quad (20)$$

again assuming that we are in the regime where the dipole approximation holds. We wish to eliminate the poorly determined quantities  $M_x^{(12)}$  and  $\xi$ , both related to the size of the dot, and the electron-phonon coupling strength and phonon velocity, in favor of measurable numbers (as far as possible). To do so, we use Eqs. (8) and (13):

$$\Gamma_{12} T_1 = \frac{4}{5} \frac{E_{10}^8}{E_Z^2} \frac{\hbar^2}{m_t \beta^2}. \quad (21)$$

Here  $E_Z = g \mu_B B$  is the Zeeman splitting,  $\Delta$  is the energy of the first excited state, which can be measured independently, by transport spectroscopy or looking at Orbach processes at higher temperatures.  $\beta$  can also be measured by other means,



though this is not straightforward.<sup>64</sup> Thus, it would take a combination of measurements to use the absolute magnitude of  $T_1$  as a test of theory. Note that this analysis assumes that the first excited state is purely orbital in nature and that the fast orbital relaxation time can be measured. The former may be ameliorated in the valley case where there is strong valley-orbital mixing, or if not,  $\Gamma_{21}$  can be replaced with the ideal valley relaxation time. The latter may be a difficult experimental constraint. Failing this, the  $1/T_1 \propto B^7$ ,  $1/T_1 \propto [1 + 2n_B(E_Z/k_B T)]$ , and the field anisotropy given by Eq. (12) provide the best tests. We note also that the field anisotropy of the spin relaxation, Eq. (12), can help determine the relative contributions of the Rashba and Dresselhaus-like SOC contributions.

We have focused on the lowest lying state configurations of a silicon quantum dot that are most relevant for quantum computing and have found that, in general, spin-based quantum computing benefits from orbital and valley states being as high in energy as possible. We began by considering phonon relaxation of excited orbital states across the same valley state in a lateral silicon QD. We found that orbital relaxation could be dramatically faster in biaxially strained silicon than in the bulk. This, for example, speeds up spin-qubit initialization via optical pumping schemes<sup>29</sup> as well as possible leakage to excited states via phonon excitation. The phonon-bottleneck effect will eventually decrease the orbital relaxation rate but only for unrealistically small dots. In contrast, spin relaxation can easily be seconds (even when

the magnetic field points along the growth direction) and  $T_1$  increases for small dots and low magnetic fields. At small magnetic fields, charge noise could play a dominant role. Valley relaxation can also be long in ideal dots, especially for small valley splittings. In nonideal dots, although not quantitatively considered here, valley relaxation will likely be comparable to orbital relaxation.

The theory proposed here depends on the correct identification of excited states as either orbital excited states or valley excited states. Theoretical considerations for spin and valley relaxation in cases where the states are not purely orbital, valley, or spin—in other words, they are mixed due to, for example, disorder or surface roughness in realistic devices—and for regimes beyond small B field (where degeneracies come into play) are subjects for future work.

*Note added in proof.* Recently, a new experimental and theoretical work from one of the authors has been published (Ref. 65 and associated Supplemental Material) which extends the work in this text to that of nonideal dots and beyond the ED approximation.

## ACKNOWLEDGMENTS

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## APPENDIX

### 1. Orbital relaxation: Beyond the electric-dipole approximation

To calculate the matrix element of  $H_{ep}$  between orbital states  $m$  and  $n$  in Eq. (5) beyond the ED approximation, we begin with the full expression [see Eq. (4)]:

$$\begin{aligned} \langle n | H_{ep} | m \rangle &= \int \psi_m^* (H_{ep}) \psi_n dV \\ &= \sum_{\mathbf{q}, \lambda} \sum_{i, j} \alpha_m^i \alpha_n^j \{ \Xi_d [\mathbf{e}(\mathbf{q}, \lambda) \cdot \mathbf{q}] + \Xi_u(\mathbf{q} \cdot \mathbf{K}^{(i)}) [\mathbf{e}(\mathbf{q}, \lambda) \cdot \mathbf{K}^{(i)}] \} a_q^* \int F_i^* F_j u_{\mathbf{k}_i}^* u_{\mathbf{k}_j} e^{-i(-\mathbf{k}_i + \mathbf{k}_j + \mathbf{q}) \cdot \mathbf{r}} dV. \end{aligned} \quad (\text{A1})$$

We proceed following the derivation by Castner.<sup>14</sup> This derivation will be useful when valley relaxation is considered. A function which is periodic with the period of the lattice may be expanded in a Fourier series in the reciprocal lattice vectors  $\mathbf{Q}_\nu$ , so

$$u_{\mathbf{k}_i}^*(\mathbf{r}) u_{\mathbf{k}_j}(\mathbf{r}) = \sum_{\nu} C_{\mathbf{k}_i - \mathbf{k}_j}^{\nu} e^{i\mathbf{Q}_\nu \cdot \mathbf{r}},$$

and the integral in  $M_{mn}$  becomes

$$\sum_{\nu} C_{\mathbf{k}_i - \mathbf{k}_j}^{\nu} \int |F_i|^2 e^{-i(-\mathbf{k}_i + \mathbf{k}_j + \mathbf{q} - \mathbf{Q}_\nu) \cdot \mathbf{r}} d\mathbf{r}.$$

The envelope probability can be Fourier transformed,

$$|F_i(\mathbf{r})|^2 = \frac{1}{(2\pi)^3} \sum_{\mathbf{k}''} f(\mathbf{k}'') e^{i\mathbf{k}'' \cdot \mathbf{r}}.$$

Plugging this into the integral in  $M_{mn}$  gives

$$\sum_{\nu} C_{\mathbf{k}_i - \mathbf{k}_j}^{\nu} \int \frac{1}{(2\pi)^3} \sum_{\mathbf{k}''} f(\mathbf{k}'') e^{-i(-\mathbf{k}_i + \mathbf{k}_j + \mathbf{q} - \mathbf{Q}_\nu - \mathbf{k}'') \cdot \mathbf{r}} d\mathbf{r},$$

which equals

$$\sum_{\nu} C_{k_i-k_j}^{\nu} \frac{1}{(2\pi)^3} \sum_{\mathbf{k}''} f(\mathbf{k}'') \delta^3(\mathbf{k}_i - \mathbf{k}_j - \mathbf{q} + \mathbf{Q}_{\nu} + \mathbf{k}'') = \sum_{\nu} C_{k_i-k_j}^{\nu} f^{ij}(-\mathbf{k}_i + \mathbf{k}_j + \mathbf{q} - \mathbf{Q}_{\nu}).$$

Finally, the matrix element is given by

$$\langle n | H_{ep} | m \rangle = \sum_{i,j} \alpha_m^i \alpha_n^j [\Xi_d(\mathbf{e}_s \cdot \mathbf{q}) + \Xi_u(\mathbf{q} \cdot \mathbf{K}^{(i)})(\mathbf{e}_s \cdot \mathbf{K}^{(i)})] a_q^* \sum_{\nu} C_{k_i-k_j}^{\nu} f^{ij}(-\mathbf{k}_i + \mathbf{k}_j + \mathbf{q} - \mathbf{Q}_{\nu}). \quad (\text{A2})$$

We are calculating an intravalley scattering process (orbital relaxation with no change in valley state) so  $\mathbf{Q}_{\nu} = 0$  is the dominant term,  $\mathbf{k}_i = \mathbf{k}_j$ , and  $\alpha_m = \alpha_n$  which gives

$$\langle n | H_{ep} | m \rangle = \sum_{i,j} \alpha_m^i \alpha_n^j \{ \Xi_d[\mathbf{e}(\mathbf{q}, \lambda) \cdot \mathbf{q}] + \Xi_u(\mathbf{q} \cdot \mathbf{K}^{(i)})[\mathbf{e}(\mathbf{q}, \lambda) \cdot \mathbf{K}^{(i)}] \} C_{k_i-k_j}^{\nu} f^{mn}(\mathbf{q}),$$

and for the most relevant transition,

$$\langle 1 | H_{ep} | 0 \rangle = \sum_{i,j} \alpha_m^i \alpha_n^j [\Xi_d q_l + \Xi_u e_z q_z] C_{k_i-k_j}^0 f^{12}(\mathbf{q}) = [\Xi_d q_l + \Xi_u e_z q_z] C_{k_i-k_j}^0 f^{12}(\mathbf{q}),$$

where  $q_l = q_{\Delta} = E_{10}/\hbar v_l$  for longitudinal phonons but  $q_{\ell} = 0$  for transverse phonons ( $q_{\Delta} = E_{10}/\hbar v_l$ ).  $C_{k_i-k_j}^0$  is the first coefficient in the Bloch wave expansion (see main text for the largest contributions).

The envelope function of the ground-state QD wave function in the absence of a magnetic field in the lowest approximation is a product of Gaussians,  $F^{(1)}(\mathbf{r}) = F(x, y, z) = F(x)F(y)F(z)$ , where  $F(x) = (2/\pi)^{1/4} x_0^{-1/2} \exp(-x^2/x_0^2)$ ,  $F(y) = (2/\pi)^{1/4} y_0^{-1/2} \exp(-y^2/y_0^2)$ , and  $F(z) = (2/\pi)^{1/4} z_0^{-1/2} \exp(-z^2/z_0^2)$ . The excited state, if  $y_0 > x_0 \gg z_0$ , is  $F^{(2)}(\mathbf{r}) = F(x, y, z) = F(x)F^{(2)}(y)F(z)$ , where

$$F^{(2)}(y) = (2/\sqrt{y_0^3})(2/\pi)^{1/4} y \exp(-y^2/y_0^2).$$

Then, the overlap integral is given by

$$\begin{aligned} f^{(12)}(\mathbf{q}) &= \int F^{(2)}(\mathbf{r}) e^{i\mathbf{q}\cdot\mathbf{r}} F^{(1)}(\mathbf{r}) d\mathbf{r}, \\ f^{(1)}(q_x) f^{(12)}(q_y) f^{(1)}(q_z) &= \int F^{(1)}(x)^2 e^{iq_x x} dx \int F^{(2)}(y) e^{iq_y y} F^{(1)}(y) dy \int F^{(1)}(z)^2 e^{iq_z z} dz \\ &= \exp\left(-\frac{1}{8} x_0^2 q_x^2\right) \frac{i y_0}{2} q_y \exp\left(-\frac{1}{8} y_0^2 q_y^2\right) \exp\left(-\frac{1}{8} z_0^2 q_z^2\right). \end{aligned}$$

Inserting these into the golden rule, we find that

$$\Gamma_{10} = \frac{2\pi}{\hbar} \sum_{\mathbf{q}, s} |M_{10}|^2 \delta(\Delta - \hbar\omega_{\mathbf{q}, s}) \quad (\text{A3})$$

$$= \frac{2\pi}{\hbar} \sum_s \frac{V}{(2\pi)^3} \int_0^{\infty} q^2 dq \int \sin\theta d\theta d\phi |M_{10}|^2 \frac{1}{|\hbar v_s|} \delta\left(q - \frac{E_{21}}{\hbar v_s}\right), \quad (\text{A4})$$

continuing

$$\Gamma_{10} = \frac{2\pi}{\hbar^2} \sum_s \frac{V}{(2\pi)^3} \int_0^{\infty} q^2 dq \int \sin\theta d\theta d\phi \frac{1}{v_s} |[\Xi_d q_l + \Xi_u e_z q_z] a_q^* C_{k_i}^0 f^{12}(\mathbf{q})|^2 \delta(q - q_{\Delta}) = \frac{(n_q + 1)(C_{k_0}^0)^2}{2(2\pi)^2 \rho_{Si} \hbar} \sum_s q_{\Delta s} I_s.$$

We are left with calculating the three angular integrals  $I$  which have units  $\text{kg}^2/\text{s}^2$  and are defined as

$$\begin{aligned} I_s &= \int \sin\theta \frac{1}{v_s^2} |[\Xi_d q_{\Delta l} + \Xi_u e_z q_{\Delta s} \hat{q}_z] f^{12}(q_{\Delta s}, \hat{\mathbf{q}})|^2 d\theta d\phi \\ &= \int \sin\theta \frac{1}{v_s^2} [\Xi_d q_{\Delta l} + \Xi_u e_z q_{\Delta s} \hat{q}_z]^2 \exp\left(-\frac{1}{4} x_0^2 q_x^2\right) \frac{y_0^2}{4} q_y^2 \exp\left(-\frac{1}{4} y_0^2 q_y^2\right) \exp\left(-\frac{1}{4} z_0^2 q_z^2\right) d\theta d\phi. \end{aligned}$$

We can immediately point out that  $I_{t_2} = 0$  because  $e_z(t_1) = 0$ . Then,

$$I_s = \int \sin \theta \frac{q_{\Delta s}^2 y_0^2}{4v_s^2} [\Xi_d q_{\Delta l} + \Xi_u e_{zs} q_{\Delta s} \cos \theta]^2 \exp\left(-\frac{1}{4} x_0^2 q_{\Delta s}^2 \sin^2 \theta \cos^2 \phi\right) \\ \times \sin^2 \theta \sin^2 \phi \exp\left(-\frac{1}{4} y_0^2 q_{\Delta s}^2 \sin^2 \theta \sin^2 \phi\right) \exp\left(-\frac{1}{4} z_0^2 q_{\Delta s}^2 \cos^2 \theta\right) d\theta d\phi.$$

If we assume an approximately circular dot in  $x$  and  $y$ , then using  $\cos^2 \phi + \sin^2 \phi = 1$  we can do the  $\phi$  integral easily,

$$I_s = \pi \exp\left(-\frac{1}{4} x_0^2 q_{\Delta s}^2\right) \int \frac{q_{\Delta s}^2 y_0^2}{4v_s^2} [\Xi_d q_{\Delta l} + \Xi_u e_{zs} q_{\Delta s} x]^2 (1-x^2) \exp\left[\frac{1}{4} (x_0^2 - z_0^2) q_{\Delta s}^2 x^2\right] dx, \\ I_l = \pi \exp\left(-\frac{1}{4} x_0^2 q_{\Delta s}^2\right) \frac{q_{\Delta l}^2 y_0^2}{4v_l^2} [\Xi_d^2 q_{\Delta l}^2 (A_l^0 - A_l^2) + 2\Xi_d \Xi_u q_{\Delta l}^2 (A_l^2 - A_l^4) + \Xi_u^2 q_{\Delta l}^2 (A_l^4 - A_l^6)], \\ I_{t_2} = \pi \exp\left(-\frac{1}{4} x_0^2 q_{\Delta l}^2\right) \frac{q_{\Delta l}^2 y_0^2}{4v_l^2} \Xi_u^2 q_{\Delta l}^2 [A_l^2 - 2A_l^4 + A_l^6],$$

where

$$A_s^n = \int_1^{-1} x^n \exp\left[\frac{1}{4} (x_0^2 - z_0^2) q_{\Delta s}^2 x^2\right].$$

Finally, the orbital relaxation rate for a parabolic dot (in all three dimensions) from its first excited state is given by

$$\Gamma_{10} = \frac{(n_q + 1) (C_{k_0}^0)^2 \pi y_0^2}{2(2\pi)^2 \rho_{Si} \hbar} \frac{1}{4} \left\{ \frac{\exp(-\frac{1}{4} x_0^2 q_{\Delta l}^2)}{v_l^2} \frac{E_{10}^5}{\hbar^5 v_l^5} [\Xi_d^2 (A_l^0 - A_l^2) + 2\Xi_d \Xi_u (A_l^2 - A_l^4) + \Xi_u^2 (A_l^4 - A_l^6)] \right. \quad (A5)$$

$$\left. + \frac{\exp(-\frac{1}{4} x_0^2 q_{\Delta l}^2)}{v_l^2} \frac{E_{10}^5}{\hbar^5 v_l^5} \Xi_u^2 [A_l^2 - 2A_l^4 + A_l^6] \right\}. \quad (A6)$$

This reduces exactly to the expression for orbital relaxation within the ED approximation, given in Eq. (6), when  $q_{\Delta s}^2 = 0$ .

## 2. Valley relaxation (ideal case)

### a. Valley relaxation in a 3D parabolic quantum dot

We consider valley relaxation in a lateral silicon quantum dot. We begin where we left off in our exact consideration of orbital relaxation. Our expression for the electron-phonon matrix element, Eq. (A2), was

$$M_{mn} = \sum_{i,j} \alpha_m^i \alpha_n^j \{ \Xi_d [\mathbf{e}(\mathbf{q}, \lambda) \cdot \mathbf{q}] + \Xi_u (\mathbf{q} \cdot \mathbf{K}^{(i)}) [\mathbf{e}(\mathbf{q}, \lambda) \cdot \mathbf{K}^{(i)}] \} a_q^* \sum_{\nu} C_{k_i}^{\nu} f^{ij} (-\mathbf{k}_i + \mathbf{k}_j + \mathbf{q} - \mathbf{Q}_{\nu}),$$

where  $f$  is the Fourier transform of the envelope function overlap integral. Since the valley transition involves a change in crystal momentum, there are no intravalley terms from this expression and we must consider high-wave-number phonons that can connect the two valleys which are separated in the first Brillouin zone by  $2k_{\min}$ . In this case,  $i \neq j$  and  $\mathbf{k}_j = -\mathbf{k}_i$  and the matrix element becomes

$$M_{mn}(i \neq j) = \sum_{i,j} \alpha_m^i \alpha_n^j \{ \Xi_d q_l + \Xi_u (\mathbf{q} \cdot \mathbf{K}^{(i)}) [\mathbf{e}(\mathbf{q}, \lambda) \cdot \mathbf{K}^{(i)}] \} a_q^* \sum_{\nu} C_{k_i}^{\nu} f^{ij} (-2\mathbf{k}_i + \mathbf{q} - \mathbf{Q}_{\nu}),$$

where  $q_l = q_{\Delta}$  for longitudinal phonons but zero for transverse phonons ( $q_{\Delta} = \Delta/hv_s$ ). The matrix element will only be large for values of  $\mathbf{q} \approx 2\mathbf{k}_i - \mathbf{K}_{\nu}$ . The shortest wave number phonon to connect the two valleys is the Umklapp phonon across the Brillouin zone, where  $|q_u| = 2(q_{\max} - q_{\min})$ , where  $q_{\max} = \pi/a_{Si}$ . Thus, for the  $+z$  and  $-z$  valleys,

$$M_{\nu} = \frac{1}{2} [\Xi_d q_l + \Xi_u e_z q_z] a_q^* C_{k_0}^1 [f^{(1)}(-q_u \hat{z} + \mathbf{q}) - f^{(1)}(q_u \hat{z} + \mathbf{q})]. \quad (A7)$$

This is just the result of Castner as a component of his calculation of Raman spin transitions in donors. The major difference between the donor and QD calculations (in the ideal case) are due to the different envelope functions (impurity vs parabolic). We

next require the Fourier transform of the QD envelope function:

$$\begin{aligned} f^{(1)}(\mathbf{q}) &= \int F^{(1)}(\mathbf{r})^2 e^{i\mathbf{q}\cdot\mathbf{r}} d\mathbf{r}, \\ f^{(1)}(q_x)f^{(1)}(q_y)f^{(1)}(q_z) &= \int F^{(1)}(x)^2 e^{iq_x x} dx \int F^{(1)}(y)^2 e^{iq_y y} dy \int F^{(1)}(z)^2 e^{iq_z z} dz \\ &= \exp\left(-\frac{1}{8}x_0^2 q_x^2\right) \exp\left(-\frac{1}{8}y_0^2 q_y^2\right) \exp\left(-\frac{1}{8}z_0^2 q_z^2\right). \end{aligned}$$

Again we have considered the case where the  $z$  dimension of the wave function can be approximated as a simple Gaussian (which is for our consideration a good approximation).

Looking at Eq. (A7), we see that the  $f$  functions are heavily peaked at  $q_u$  ( $\approx 0.3q_{\max} = 0.3\pi/a = 1.74 \times 10^9 \text{ m}^{-1}$ ) in the  $z$  direction and at 0 in the  $x$  and  $y$  directions. Since phonons of this magnitude are needed to connect the two valleys, resonant phonons close to this will increase the matrix element leading to increased relaxation. However, slightly off-resonant phonons can also cause a transition due to the widths of the  $f$  functions which broaden as  $z_0$  gets smaller (see Fig. 9). In donors, the valley splitting tends to be around 11 meV, not far off of this wave vector. In silicon quantum dots, the theoretically predicted values of the valley splitting range from 0 to 3 meV, depending on the extent of the  $z$  wave function.

To calculate the valley transition rate we employ the golden rule,

$$\Gamma_v = \frac{2\pi}{\hbar} \sum_{\mathbf{q},s} |M_v|^2 \delta(\Delta - \hbar\omega_{\mathbf{q},s}), \quad (\text{A8})$$

$$= \frac{2\pi}{\hbar} \sum_s \frac{V}{(2\pi)^3} \int_0^\infty q^2 dq \int \sin\theta d\theta d\phi |M_v|^2 \frac{1}{|\hbar v_s|} \delta\left(q - \frac{\Delta}{\hbar v_s}\right), \quad (\text{A9})$$

where we have summed over phonons. At cryogenic temperature there are absolutely no large-wave-number phonons, so we need only consider spontaneous emission. Incorporating our expression for the matrix element, we find (with  $F(q_u, \mathbf{q}) = [f^{(1)}(-q_u \hat{z} + \mathbf{q}) - f^{(1)}(q_u \hat{z} + \mathbf{q})]$ ) that

$$\begin{aligned} \Gamma_v &= \frac{2\pi}{\hbar^2} \sum_s \frac{V}{(2\pi)^3} \int_0^\infty q^2 dq \int \sin\theta d\theta d\phi \frac{1}{v_s} \left| \frac{1}{2} [\Xi_d q_l + \Xi_u e_z q_z] a_q^* C_{k_0}^1 F(q_u, \mathbf{q}) \right|^2 \delta(q - q_\Delta) \\ &= \frac{(n_q + 1)(C_{k_0}^1)^2}{8(2\pi)^2 \rho_{\text{Si}} \hbar} \sum_s \int_0^\infty q \int \sin\theta \frac{1}{v_s^2} |[\Xi_d q_l + \Xi_u e_z q_z] F(q_u, \mathbf{q})|^2 \delta(q - q_\Delta) d\theta d\phi dq \\ &= \frac{(n_q + 1)(C_{k_0}^1)^2}{8(2\pi)^2 \rho_{\text{Si}} \hbar} \sum_s q_{\Delta s} I_s. \end{aligned}$$

Taking the  $\delta$  function, the rate becomes

$$\Gamma_v = \frac{(n_q + 1)(C_{k_0}^1)^2}{8(2\pi)^2 \rho_{\text{Si}} \hbar} \sum_s q_{\Delta s} \int \sin\theta \frac{1}{v_s^2} |[\Xi_d q_{\Delta l} + \Xi_u e_z q_{\Delta s} \hat{q}_z] F(q_u, q_{\Delta s} \hat{\mathbf{q}})|^2 d\theta d\phi = \frac{(n_q + 1)(C_{k_0}^1)^2}{8(2\pi)^2 \rho_{\text{Si}} \hbar} \sum_s q_{\Delta s} I_s,$$

where  $\hat{\mathbf{q}} = \mathbf{e}_l$ . We are again left with calculating three angular integrals  $I$  which have units ( $\text{kg}^2/\text{s}^2$ ) and are defined as

$$I_{s=l,t_1,t_2} = \int_0^{2\pi} \int_0^\pi \sin\theta \frac{1}{v_s^2} |[\Xi_d q_{\Delta l} + \Xi_u e_z q_{\Delta s} \hat{q}_z] [f^{(1)}(-q_u \hat{z} + q_{\Delta s} \hat{\mathbf{q}}) - f^{(1)}(q_u \hat{z} + q_{\Delta s} \hat{\mathbf{q}})]|^2 d\theta d\phi, \quad (\text{A10})$$

where  $I_t = 0$ . If we assume that the dot is circular, then the  $f$  functions simplify,

$$\begin{aligned} f^{(1)}(\pm q_u \hat{z} + q_{\Delta} \hat{\mathbf{q}}) &= \exp\left[-\frac{1}{8}x_0^2 (q_{\Delta} \hat{q}_x)^2 - \frac{1}{8}x_0^2 (q_{\Delta} \hat{q}_y)^2\right] \exp\left[-\frac{1}{8}z_0^2 (q_{\Delta} \hat{q}_z \pm q_u)^2\right] \\ &= \exp\left(-\frac{1}{8}x_0^2 q_{\Delta}^2 \sin^2\theta\right) \exp\left[-\frac{1}{8}z_0^2 (q_{\Delta} \cos\theta \pm q_u)^2\right]. \end{aligned}$$

Replacing  $\hat{q}$  with its components we can further simplify  $I$ :

$$\begin{aligned} I_{s=l,t_1,t_2} &= \int_0^{2\pi} \int_0^\pi \sin\theta \frac{1}{v_s^2} \left| [\Xi_d q_{\Delta l} + \Xi_u e_z q_{\Delta s} \cos\theta] \exp\left(-\frac{1}{8} x_0^2 q_{\Delta}^2 \sin^2\theta\right) \right\|^2 d\theta d\phi \\ &= \int_0^{2\pi} \int_0^\pi \sin\theta \frac{1}{v_s^2} [\Xi_d q_{\Delta l} + \Xi_u q_{\Delta s} e_z \cos\theta]^2 \exp\left(-\frac{1}{4} x_0^2 q_{\Delta}^2 \sin^2\theta\right) \{\}^2 d\theta d\phi, \end{aligned}$$

where

$$\begin{aligned} \{\}^2 &= \left\{ \exp\left[-\frac{1}{8} z_0^2 (q_{\Delta l} \cos\theta - q_u)^2\right] - \exp\left[-\frac{1}{8} z_0^2 (q_{\Delta l} \cos\theta + q_u)^2\right] \right\}^2 \\ &= \exp\left(-\frac{1}{4} z_0^2 q_u^2\right) \exp\left(-\frac{1}{4} z_0^2 [q_{\Delta}^2 \cos^2\theta]\right) 4 \sinh^2\left(\frac{1}{8} z_0^2 2q_{\Delta} q_u \cos\theta\right). \end{aligned}$$

So, taking the trivial  $\phi$  integral (no  $e_{zs}$  depends on  $\phi$ ),

$$\begin{aligned} I_{s=l,t_1,t_2} &= 8\pi \exp\left(-\frac{1}{4} z_0^2 q_u^2\right) \int_0^\pi \sin\theta d\theta \frac{1}{v_s^2} [\Xi_d q_{\Delta l} + \Xi_u q_{\Delta s} e_z \cos\theta]^2 \\ &\quad \times \exp\left(-\frac{1}{4} x_0^2 q_{\Delta l}^2 \sin^2\theta\right) \exp\left(-\frac{1}{4} z_0^2 [q_{\Delta}^2 \cos^2\theta]\right) \sinh^2\left(\frac{1}{8} z_0^2 2q_{\Delta} q_u \cos\theta\right). \end{aligned}$$

Now we explicitly consider the integrals for  $s = l$  and  $s = t_2$ . Evaluating the longitudinal and transverse ( $t_2$ ) integrals separately,

$$\begin{aligned} I_l &= 8\pi \exp\left(-\frac{1}{4} z_0^2 q_u^2\right) \exp\left(-\frac{1}{4} x_0^2 q_{\Delta l}^2\right) \frac{q_{\Delta l}^2}{v_l^2} \\ &\quad \times \int_1^{-1} dx [\Xi_d^2 + 2\Xi_d \Xi_u x^2 + \Xi_u^2 x^4] \exp\left(\frac{1}{4} q_{\Delta l}^2 [x_0^2 - z_0^2] x^2\right) \sinh^2\left(\frac{1}{8} z_0^2 2q_{\Delta l} q_u x\right) \end{aligned}$$

and, similarly,

$$I_{t_2} = 8\pi \exp\left(-\frac{1}{4} z_0^2 q_u^2\right) \exp\left(-\frac{1}{4} x_0^2 q_{\Delta t}^2\right) \frac{q_{\Delta t}^2}{v_t^2} \int_1^{-1} dx \Xi_u^2 [x^2 - x^4] \exp\left(\frac{1}{4} q_{\Delta t}^2 [x_0^2 - z_0^2] x^2\right) \sinh^2\left(\frac{1}{8} z_0^2 2q_{\Delta t} q_u x\right).$$

The integrals have no analytical solution, so we define a numerically tractable integral function

$$P_s^n = \int_{-1}^1 x^n \exp[Ax^2] \sinh^2[Bx] dx,$$

where

$$A = \frac{1}{4} q_{\Delta s}^2 [x_0^2 - z_0^2], \quad B = \frac{1}{8} z_0^2 2q_{\Delta s} q_u,$$

and rewrite our solutions:

$$I_l = 8\pi \exp\left(-\frac{1}{4} z_0^2 q_u^2\right) \exp\left(-\frac{1}{4} x_0^2 q_{\Delta l}^2\right) \frac{q_{\Delta l}^2}{v_l^2} [\Xi_d^2 P_l^0 + 2\Xi_d \Xi_u P_l^2 + \Xi_u^2 P_l^4]$$

and

$$I_{t_2} = 8\pi \exp\left(-\frac{1}{4} z_0^2 q_u^2\right) \exp\left(-\frac{1}{4} x_0^2 q_{\Delta t}^2\right) \frac{q_{\Delta t}^2}{v_t^2} \Xi_u^2 [x^2 P_t^2 - x^4 P_t^4].$$

Finally, the valley relaxation rate of a parabolic, circular quantum dot in a [001]-strained silicon quantum well is ( $n_q = 0$ ),

$$\Gamma_v = (n_q + 1) (C_{k_0}^1)^2 \frac{\exp\left(\frac{-z_0^2 q_u^2}{4}\right)}{4\pi \rho_{Si} \hbar} \left[ \exp\left(\frac{-x_0^2 q_{\Delta l}^2}{4}\right) \frac{q_{\Delta l}^3}{v_l^2} (\Xi_d^2 P_l^0 + 2\Xi_d \Xi_u P_l^2 + \Xi_u^2 P_l^4) + \exp\left(\frac{-x_0^2 q_{\Delta t}^2}{4}\right) \frac{q_{\Delta t}^3}{v_t^2} \Xi_u^2 (P_t^2 - P_t^4) \right].$$

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